

Quantum information processing with integrated silicon carbide photonics

Cite as: J. Appl. Phys. **131**, 130901 (2022); <https://doi.org/10.1063/5.0077045>

Submitted: 29 October 2021 • Accepted: 12 March 2022 • Published Online: 01 April 2022

 Sridhar Majety,  Pranta Saha,  Victoria A. Norman, et al.

COLLECTIONS

Paper published as part of the special topic on [Defects in Semiconductors 2022](#)

 This paper was selected as Featured



View Online



Export Citation



CrossMark

ARTICLES YOU MAY BE INTERESTED IN

[Characterization methods for defects and devices in silicon carbide](#)

Journal of Applied Physics **131**, 140903 (2022); <https://doi.org/10.1063/5.0077299>

[Developing silicon carbide for quantum spintronics](#)

Applied Physics Letters **116**, 190501 (2020); <https://doi.org/10.1063/5.0004454>

[Material platforms for defect qubits and single-photon emitters](#)

Applied Physics Reviews **7**, 031308 (2020); <https://doi.org/10.1063/5.0006075>

[Learn More](#)

Journal of
Applied Physics **Special Topics** Open for Submissions

Quantum information processing with integrated silicon carbide photonics

F

Cite as: J. Appl. Phys. 131, 130901 (2022); doi: 10.1063/5.0077045

Submitted: 29 October 2021 · Accepted: 12 March 2022 ·

Published Online: 1 April 2022



View Online



Export Citation



CrossMark

Sridhar Majety,^{1,a)} Pranta Saha,¹ Victoria A. Norman,^{1,2} and Marina Radulaski¹

AFFILIATIONS

¹Department of Electrical and Computer Engineering, University of California, Davis, California 95616, USA²Department of Physics, University of California, Davis, California 95616, USA**Note:** This paper is part of the Special Topic on Defects in Semiconductors.**a) Author to whom correspondence should be addressed:** smajety@ucdavis.edu

ABSTRACT

Color centers in wide bandgap semiconductors are prominent candidates for solid-state quantum technologies due to their attractive properties including optical interfacing, long coherence times, and spin-photon and spin-spin entanglement, as well as the potential for scalability. Silicon carbide color centers integrated into photonic devices span a wide range of applications in quantum information processing in a material platform with quantum-grade wafer availability and advanced processing capabilities. Recent progress in emitter generation and characterization, nanofabrication, device design, and quantum optical studies has amplified the scientific interest in this platform. We provide a conceptual and quantitative analysis of the role of silicon carbide integrated photonics in three key application areas: quantum networking, simulation, and computing.

Published under an exclusive license by AIP Publishing. <https://doi.org/10.1063/5.0077045>

I. INTRODUCTION

Quantum mechanical effects such as superposition and entanglement open the doors to novel quantum information processing (QIP) technologies in communication, computation, sensing, and metrology that are hard or impossible to build using conventional classical technologies. Among various implementations with superconducting qubits, trapped ions, and neutral atoms, the solid-state systems with optically addressable spin states (quantum dots, crystal defects) have shown the most promise in distributed QIP owing to the ability to create entanglement between the spin degree of freedom and a photon(s), serving as stationary and flying qubit(s), respectively.¹ Having photons as couriers of quantum information is beneficial, as they are unaffected by thermal noise and can travel long distances via fiber-optic cable without interacting with each other. Flying qubits from separate systems can be transported to a common location to perform entanglement swapping, thus creating remote entanglement between systems without their direct interaction. Moreover, solid-state platforms are scalable and offer a chip-scale integration.

For the purposes of QIP, one of the primary requirements is the ability of a single photon emitter (SPE) to generate indistinguishable photons that can be mutually entangled. There have been

notable strides using quantum dots for this purpose;^{2,3} however, the significant variability in the emission wavelengths (with the quantum dot size, charge, and temperature) has been challenging to overcome in a scalable fashion. On the other hand, the color centers, which are point defects in wide bandgap semiconductors that behave like quasi-atoms, have nearly identical and well reproducible properties.

Color center platforms have not yet realized their full QIP potential. Several remarkable demonstrations have been made in this regard, such as spin-photon entanglement,⁴ remote entanglement of solid-state spins separated by 1.3 km,¹ a multimode quantum network,⁵ implementation of fault-tolerant operation of a logical qubit,⁶ memory-enhanced quantum communication,⁷ and a quantum register that uses nine nuclear spins coupled to a single electron spin, with quantum memory nearing one minute.⁸ Most of these demonstrations were made using the nitrogen-vacancy (NV) center in diamond, which has defined the color center field that is now populated by a variety of quantum emitters with complementary or advanced properties.

There are several challenges to overcome in order to scale the experimental demonstrations to large-scale implementations and to harness the full potential of quantum technologies. For applications

in quantum networks, further research is required to maximize the collection of emitted photons into fibers, waveguides, and minimize the optical losses in the fiber-optic cable and operational errors. The field of quantum computation can be further boosted by developing quantum memories with long coherence times (few seconds or higher), high-fidelity single-shot readouts of spin states, and high-fidelity quantum gates. Color centers emerging in diamond and silicon carbide (SiC) are optically addressable with properties like long spin coherence times, nearly identical emission wavelengths. These properties coupled with methods like defect engineering, nanophotonic integration, and better error correction protocols can overcome some of the existing challenges.

There have been multiple useful review articles on silicon carbide and color center photonics,^{9–14} which guide the reader through the variety of emitter properties, devices, and techniques. In this Perspective, we fill the gap in understanding of the concepts of the next generation of integrated optical quantum hardware. We believe that our perspectives will inform scientists working on tangential areas of semiconductor defects and quantum information processing interested in the opportunities in integrated SiC quantum photonics. We open by discussing quantum optical properties of SiC color centers and suitability for quantum hardware, followed by a review of their integration into photonic devices. We then outline three key applications in quantum networking, simulation, and computing and discuss their implementation prospects with integrated color center photonics in SiC.

II. QIP WITH COLOR CENTERS IN SiC

In this section, we discuss methods for characterizing quantum optical properties of SiC color centers, review the set of characterized emitters in the field, and discuss how their properties are suitable for quantum information processing.

A. Color centers in SiC

In this section, we discuss the color centers in the most common polytypes of SiC, i.e., 3C-SiC (cubic lattice), 4H-, and 6H-SiC (hexagonal lattice). SiC hosts a variety of color centers like divacancy, silicon vacancy, nitrogen vacancy, carbon antisite-vacancy pair, and transition metal defects (chromium, vanadium, molybdenum, tungsten) with emission wavelengths in the near infrared region as shown in Fig. 1. Each defect in the lattice can exist in multiple orientations due to the presence of inequivalent lattice sites: hexagonal-like (h) and cubic-like (k). The defects in SiC exist naturally in the as-grown material or can be *in situ* doped during the crystal growth process. However, most of the studied color centers are generated through implantation where projectiles (electrons, protons, neutrons, ions) with sufficient energy are penetrated through the material surface. The implantation is followed by annealing in vacuum or inert atmosphere to activate the implants. This also helps repair the crystal lattice damage caused during implantation, though not completely.¹⁵ The residual damage can create pathways for decoherence of the electron spin, which is a disadvantage while building QIP hardware. This can partly be overcome by using lighter projectiles like electrons, protons (over heavier ions) on *in situ* doped substrates. In diamond, low energy ions were used to create shallow defects

followed by growth of an high-quality epitaxial layer,^{16,17} but this is not applicable to SiC due to large epitaxial growth temperatures.

The neutral divacancy defect ($V_{Si}V_C^0$) in SiC consists of a pair of neighboring silicon and carbon vacancies. The different possible orientations for each of the vacancies in 4H-SiC result in the photoluminescence of the divacancy to have six sharp lines (PL1–PL6) in the wavelength range of 1100 nm (PL1, PL2—axial divacancies and PL3, PL4—basal divacancies).¹⁸ Divacancy is a spin-1 system (like diamond NV center), but it has advantageous properties like Debye–Waller factor (DWF) of 5%,¹⁹ highly spin dependent optical fine structure (high-fidelity initialization and single shot readout),²⁰ and spin-coherence time of up to 5 s.²¹ At the emission wavelengths of the divacancies, the fidelity of quantum frequency conversion to a telecommunications band is higher than for NV centers in diamond.²²

The negatively charged silicon vacancy (V_{Si}^-) in SiC is formed at the site of a missing Si atom in the lattice and is a spin-3/2 defect. In 4H-SiC, V_{Si}^- has two inequivalent lattice sites (h, k), resulting in emission spectrum consisting of two ZPLs i.e., V1 (861.6 nm) and V2 (916.5 nm).^{23,24} Similarly in 6H-SiC, V_{Si}^- has three inequivalent lattice sites (h, k1, k2) leading to an emission spectrum with three ZPLs, i.e., V1 (864.7 nm), V2 (886.3 nm), and V3 (907.1 nm).^{23,24} The h- V_{Si}^- (V1 center) in 4H-SiC which has 8% of emission into the ZPL at 4K²⁵ and millisecond spin coherence times (under dynamical decoupling)^{26,27} provides avenues for high-fidelity spin–photon entanglement²⁸ and deterministic spin initialization.^{29,30} V_{Si}^- is well-suited for photonic integration due to its single spin orientation along the c axis for all inequivalent lattice sites,^{23,31} which is necessary for their deterministic orientation in devices. Moreover, the optical transitions in h- V_{Si}^- are decoupled from charge fluctuations³² resulting in low spectral diffusion in an emitter ensemble³³ and making it robust to surface charge fluctuations in nanofabricated devices.

The negatively charged nitrogen vacancy ($N_C V_{Si}^-$) in SiC consists of a substitutional nitrogen atom at a carbon site adjacent to a silicon vacancy. The emission has multiple ZPLs corresponding to the inequivalent lattice sites with emission wavelengths close to the telecommunication range, making it suitable for low-loss fiber transmission.^{34–37} A recent study has identified the emission wavelength of the NV center in 3C-SiC at 1289 nm³⁸ correcting the previously reported value of 1468 nm.³⁶ Coherent control of NV spins at room temperature,³⁹ robust photon purity, and photostability of single NV centers at elevated temperatures⁴⁰ have been demonstrated. The possibility of coupling electron spin of the NV-center to the nuclear spin of the substitutional nitrogen should be studied for quantum memory applications.

Other promising but less explored color centers in SiC are transition metal defects like chromium ion (Cr^{4+}),^{41–43} vanadium ion (V^{4+}),^{44,45} molybdenum ion (Mo^{5+}),^{46–48} tungsten ion (W^{5+}),⁴⁹ and erbium ion (Er^{3+}).^{50,51} Some of these impurities have high DWF [Cr^{4+} —73%, V^{4+} —22% (h), 39% (k)] suited for generating indistinguishable photons. Since the transition metals are not among the naturally occurring impurities in SiC, they are generated either by doping during the crystal growth or ion implantation on the wafer.

B. Quantum optical properties of color centers

Color centers create a set of ground and excited states within the bandgap of the host material and are often approximated as a

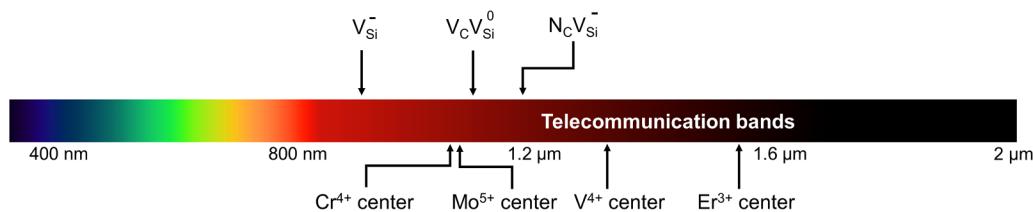


FIG. 1. Emission wavelengths of color centers in 4H-SiC on the electromagnetic spectrum.

two or a three level system. The optical properties of color centers are inspected in a photoluminescence or a photoluminescence excitation spectroscopy where the emitter is excited by an above-band or a resonant laser, respectively. The emission spectrum has two features: a sharp peak called the zero phonon line (ZPL) corresponding to a fully optical (no-phonon) transition, and a broad phonon sideband (PSB) involving transitions to the vibronic levels of the ground state. The ratio of light emitted into the ZPL is called the Debye–Waller factor (DWF).

Color centers are single photon emitters (SPEs) and as such suitable for applications in quantum light generation, spin–photon entanglement, and entanglement distribution. For these applications, it is desired to characterize the emitter's single-photon purity, which in an ideal case yields a low probability of multi-photon emission and a high emission rate (brightness).⁵² An SPE is a non-classical light source with sub-Poissonian statistics and anti-bunching behavior quantified by the zero-time second-order autocorrelation function [$g^{(2)}(\tau = 0)$] and higher order autocorrelation functions $g^{(n)}(\tau_i)$.^{53,54} The $g^{(2)}(\tau)$ function values are measured by the coincidence counts in a Hanbury–Brown–Twiss (HBT) interferometer. The HBT interferometer takes the signal from an optical mode and, using a 50:50 beam splitter, separates it into two paths terminated by single photon detectors with timed difference τ between detection events. As such, HBT is a reduced version of the Hong–Ou–Mandel interferometer (discussed in the next paragraph) shown in Fig. 2(a), where only one emitter is excited while the other one is left obsolete. If a color center is truly an SPE (and there is no luminescing background), the detectors will never have an immediate correlated detection event, yielding $g^{(2)}(\tau = 0) = 0$. In practice, however, $g^{(2)}(\tau = 0) < 0.5$ is used as a confirmation of the single-photon emission.

The coherent emission of color center light is possible through the ZPL, which presumably emits indistinguishable photons with identical spectral and temporal profiles. The Hong–Ou–Mandel (HOM) interferometer [Fig. 2(b)] is used to quantify this property with either subsequently emitted photons from the same emitter or photons emitted simultaneously from separate emitters. When two indistinguishable photons are simultaneously incident on a 50:50 beam splitter, they undergo bunching. This results in a dip in the coincidence counts at the output detectors as shown in Fig. 2(b). The degree of indistinguishability of the photons is quantified by the HOM visibility, determined by the depth of the dip in the coincidence counts. In a recent experiment with silicon vacancy in 4H-SiC²⁸, the measured visibility was $V = 0.85$, which compares well to $V = 0.90(6)$ obtained in diamond for quantum networking applications.¹

With advances in SiC material processing, an on-chip HOM interferometer, as shown in Fig. 2(a), could be fabricated. The illustrated setup has three different regions, the cavities with color centers, the waveguide beam splitter, and the superconducting nanowire single photon detectors (SNSPDs). First, the ZPL emission from each of the color centers (E1, E2) is enhanced in the cavity and coupled into a waveguide.⁵⁵ Second, the waveguides are laid out in close proximity to create coupling of optical modes. This region performs the function of a beam splitter. Third, the photons in each waveguide are detected using an SNSPD integrated on top of SiC.^{56,57} SNSPDs offer advantages like high detection efficiency, low dark count rates, and low jitter over a broad wavelength range.^{58–60} When two indistinguishable photons in each of the waveguides arrive simultaneously to the beam splitter region, they undergo bunching and are to be detected only at one of the two detectors (D1, D2).

The coherence of a quantum system is susceptible to dephasing due to the thermal fluctuations in the environment, proximity to electron and nuclear spins, and population relaxation. The rate of dephasing of the state of a quantum system (spin) is determined by the coherence time, during which the quantum system can be reliably manipulated and measured. Systems with long coherence times would allow for the application of more quantum operations, required to build large scale quantum systems with hundreds of qubits.⁶¹ For typical spin-based two-qubit quantum gates which have a predicted gate operation time of ~ 500 ns,⁶² to perform 100 000 gate operations on the quantum state, needed for the implementation of quantum error correction,⁶³ a coherence time of the order of 50 ms is required. The effect of dephasing mechanisms can be minimized using techniques like isotopic purification and dynamical decoupling. Another option to extend coherence times is using gate operations to transfer the electron spin onto a nuclear spin memory.^{8,64}

In addition to the long spin coherence that allows for complex manipulations, the quantum gates should also reach high fidelities. Recent demonstrations in divacancy centers⁶⁵ achieve 99.984% single-qubit gate fidelity, entangling CNOT gate fidelity of 99% and entangled state generation fidelity of 81%. In a recent silicon vacancy study,⁶⁶ the projected values for the single-qubit X gate and the Bell state preparation fidelities are 97% and 94%, respectively. For comparison, Bell state violation experiments in diamond used systems with fidelities for Bell state preparation of 92% and X gate of 99.8%. The quantum repeater proposals⁶⁷ target fidelity of 95% for Bell state creation. This shows that silicon carbide divacancy and silicon vacancy centers are approaching the performance suitable for quantum networks.

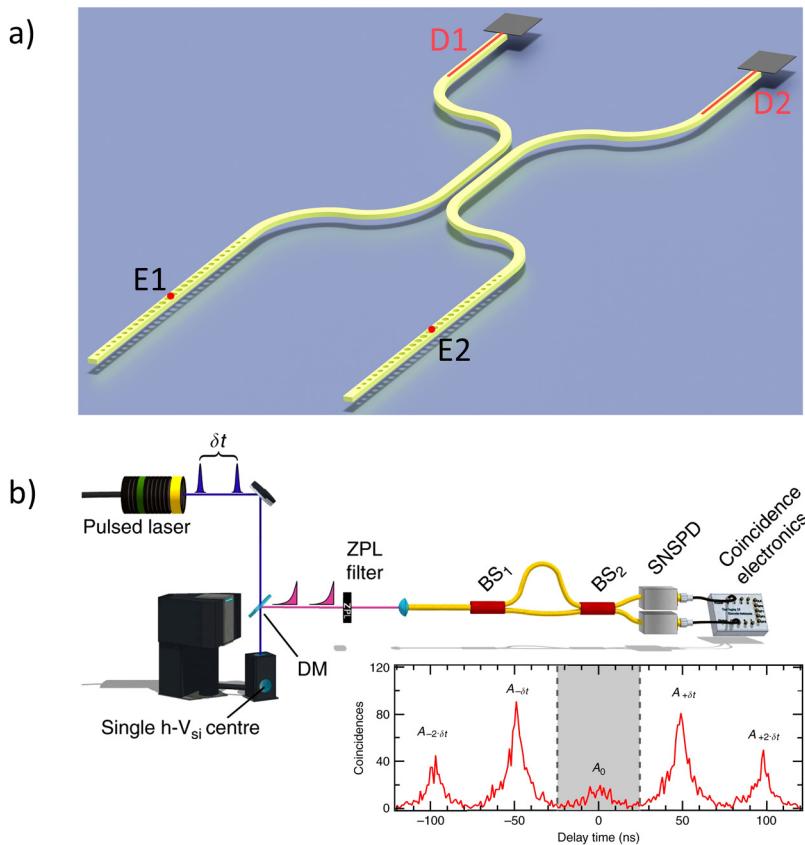


FIG. 2. (a) Perspective figure showing a concept of the on-chip realization of the HOM setup. Single color centers (E1, E2) are positioned at the center of an asymmetric cavity, resonant with the ZPL of the emitters. The emission into an asymmetric cavity preferentially propagates to one side coupling into the waveguide. The HOM interference occurs in the central region where the waveguide arms propagate in proximity mimicking a beam-splitter. The coincidence counts are measured using SNSPDs (D1, D2) that couple evanescently to the waveguide signal. (b) (top) Schematic of a Hong-Ou-Mandel interference setup to measure the indistinguishability of silicon vacancy in silicon carbide. (bottom) Plot showing two-photon coincidence counts as a function of time delay between the arrival of two photons at the superconducting nanowire single photon detectors (SNSPDs). It can be seen that the coincidence counts at zero delay has diminished, resulting in a visibility of 90%.²⁸ Reproduced with permission from Morioka *et al.*, *Nat. Commun.* 11, 2516 (2020). Copyright 2020 Author(s), licensed under a Creative Commons Attribution (CC BY) license.

C. Motivation for QIP implementations in a SiC platform

After the earliest demonstration of the NV center in diamond as a quantum system that can be individually initialized, manipulated, and measured with high fidelity at room temperature,⁶⁸ this spin-1 emitter has been the candidate for majority of the important demonstrations in the field of QIP. Despite being the traditionally most widely studied color center, diamond NV has several shortcomings including a low DWF of 3%^{69,70} that prevents achieving high entanglement rates, unavailability of single-crystal diamond wafers, emission wavelength far outside the telecommunication wavelength range (637 nm), and large spectral shifts caused by fluctuations of charges in its surrounding.⁷¹ The spectral shifts are further pronounced by proximity to surfaces,⁷² which makes this emitter challenging for efficient nanophotonic integration. It is worth noting that quantum frequency conversion of NV center emission to telecommunication wavelengths with preserved spin-photon entanglement is possible.⁷³ Other color centers explored in diamond include group-IV color centers like silicon vacancy,^{74,75} germanium vacancy,⁷⁶ tin vacancy,^{77,78} and lead vacancy.⁷⁹ These exhibit higher DWF and better optical stability, however, their emission wavelengths are far from the telecommunication bands and they have not yet demonstrated long coherence times except at mK temperatures.^{74,76}

Silicon carbide hosts a variety of color centers^{10,80} with long spin coherence times,^{81–83} excellent brightness,⁸⁴ and manipulations of nuclear spin.^{85,86} SiC offers benefits like large bandgap, high thermal conductivity, and strong second-order nonlinearity. It also hosts color centers at infra-red wavelengths and is available in several polytypes (3C-SiC, 4H-SiC, 6H-SiC) offering flexibility in terms of material properties and color center configurations. Due to its decades-long industry presence, SiC is available as high-quality single crystal wafers, has mature nanofabrication processes, and is CMOS process compatible. Most importantly, SiC color centers have longer spin coherence times than the ones in the naturally occurring diamond^{83,87} and on par with isotopically purified diamond.

III. INTEGRATION WITH PHOTONICS

Color center properties are sensitive to its environment (neighboring crystal defects, nuclear spins, surface related charges, and coupling to phonons), which poses a challenge to their naturally available forms in achieving theoretically calculated spin-optical properties. In this section, we will look into different approaches to mitigate the influence of environment on the color center properties through materials engineering and integration with nanophotonics, to achieve improved spin-optical characteristics (more indistinguishable photons, efficient optical initialization

of spin, longer coherence times, on-chip integration and scalability), and better spin-photon interfaces for applications in QIP.

A. Isotopic purification

Naturally available SiC has 1.1% ^{13}C and 4.7% ^{29}Si atoms, both with a nuclear spin of $I = 1/2$. The electron spin of the color centers and the nuclear spins have an always-on hyperfine interaction. This interaction can be used to transfer and store the electron spin state in a nuclear spin⁸⁸ (quantum memory), which has a long coherence time, on the order of a few seconds, necessary for QIP applications like error correction and entanglement purification. But, the electron spin immersed in the nuclear spin bath experiences decoherence due to fluctuating nuclear spins, that results in a nuclear spin decoherence of the nearby nuclear spin. This issue can be addressed using isotopic purification, which is the careful engineering of the nuclear environment of the color centers. A detailed study of the optimal nuclear spin concentration for maximum usable nuclear memories was done.⁶⁵ Isotopically purified SiC⁸⁹ was used to demonstrate millisecond electron spin coherence times,^{28,30,65,83} coupling to single nuclear spin with 1 kHz resolution,³⁰ and high-fidelity electron spin control (99.984%).⁶⁵

B. Passive and active photonic devices

To build a large quantum network with photon-based entanglement distribution, an important criterion is the availability of network nodes with efficient spin-photon interfaces. This can be achieved by efficiently collecting the photons emitted by a color center in the bulk and by enhancing the proportion of photons emitted into the ZPL. Passive devices couple light into an optical mode to improve collection efficiencies and low-loss guiding of the photons. Active devices improve the spontaneous emission rates of the color centers.

Color center emission in a high refractive index bulk is directed based on its dipole orientation, and when a fraction of this emission reaches the bulk-air interface, it undergoes total internal reflection, resulting in low collection efficiencies of the emitted photons. The most implemented approach for improving collection efficiencies is fabricating a solid immersion lens (SIL) on top of the color center, this ensures that the color center emission has a normal incidence at the bulk-air interface. SIL fabricated in SiC on top of a silicon vacancy^{81,90} demonstrated collection enhancements up to 3.4 times. Similar enhancements were achieved using scalable nanopillars with integrated silicon vacancies^{91,92} and erbium color centers.⁵¹ The collection efficiencies can be further enhanced by deterministic emitter positioning within these devices. Nanofabricated waveguides can be used for coupling color center emission into well-defined modes, to be routed on a chip in a nearly lossless way. High-coherence spin-optical properties of silicon vacancy integrated into SiC waveguides was demonstrated recently.⁹⁶ The emission in the waveguide mode can be coupled into a fiber for off-chip processing using free space grating couplers⁹³ and tapered fiber couplers⁹⁴ that were fabricated in diamond and yet to be developed for SiC.

Active devices like photonic crystal cavities (PCC) create light-matter interaction by confining light to sub-wavelength volumes, resulting in an increased density of states at the resonant

wavelength of the cavity. When the ZPL wavelength of the color center is resonant with the cavity, the spontaneous emission rate of the color center is enhanced through the Purcell effect. The enhancement in radiative emission is given by the Purcell factor (F_p),

$$F_p = \left[\frac{3}{4\pi^2} \left(\frac{\lambda}{n} \right)^3 \left(\frac{Q}{V} \right) \right] \left[\left| \frac{E}{E_{\max}} \right| \cos(\phi) \right] \xi.$$

F_p can be maximized by integrating a color center into a cavity with high quality factor (Q) and low cavity mode volume (V). F_p can be further boosted by optimally positioning the emitter inside the cavity, which corresponds to the spatial overlap $\left[\left| E/E_{\max} \right| \cos(\phi) \right]$ term in the equation. It should be noted from the equation above that the Q/V value required to achieve the same F_p value for different color centers depends on the DWF of the color center (ξ). Several cavity geometries like 1D nanobeam PCC,^{19,92,95} 2D PCC,^{96–98} microdisk resonator,^{99,100} triangular cross-section nanobeams¹⁰¹ were fabricated in SiC, as shown in Fig. 3 (right). V1 silicon vacancy,^{92,95} neutral divacancy,¹⁹ and Ky5 color centers^{102,103} coupled to SiC cavities demonstrated Purcell factors of up to $F_p = 120$.

The Purcell factor considers only the radiative emission resonant with the cavity, which might not be the only path for the emitter to decay from the excited state. Other pathways like non-radiative decay, emission into the phonon sideband, and pure dephasing might exist. Cooperativity (C) is the ratio of radiative emission rate through the cavity to the total decay rate of the emitter in the absence of the cavity.^{104,105} Although the spontaneous emission is enhanced through Purcell effect ($F_p > 1$), the emission through the cavity can still be smaller compared to the overall emission - weak coupling regime ($C < 1$). To achieve deterministic atom-photon interactions, the coupling between the cavity and emitter should be stronger than all the other dephasing mechanisms - strong coupling regime ($C > 1$).^{105,106} Further, emitter ensembles in a cavity with collective coupling rates to the cavity resonant mode comparable to the inhomogeneous broadening exhibit longer storage times, apt for quantum memory applications.¹⁰⁷

Putting these concepts into the context of QIP, to reach 99% coherent emission (through the ZPL) of a color center with DWF of 5% and fully optical recombination (no non-radiative recombination channels), the emission would need to be Purcell enhanced by a factor $F_p \sim 2000$. To achieve this in a representative nanocavity with a cubic wavelength mode volume $V = (\lambda/n)^3$ would require a quality factor of $Q \sim 5 \times 10^5$. Assuming now that there is a non-radiative decay channel with three times the rate of the radiative recombination, the nanocavity would need to achieve $F_p \sim 8,000$ and $Q \sim 2 \times 10^6$. Related calculations for color centers in SiC are reported in Table I. It should be noted that for color centers with closely spaced ZPLs, such as V2 silicon vacancy, additional linewidth broadening and spectral overlap should be considered when evaluating coherence properties of Purcell enhanced emission. Q-factors up to 6.3×10^5 ⁹⁸ have already been achieved in SiC nanocavities without emitters. Thus, there needs to be more research focus on color center integration into the SiC nanocavities.

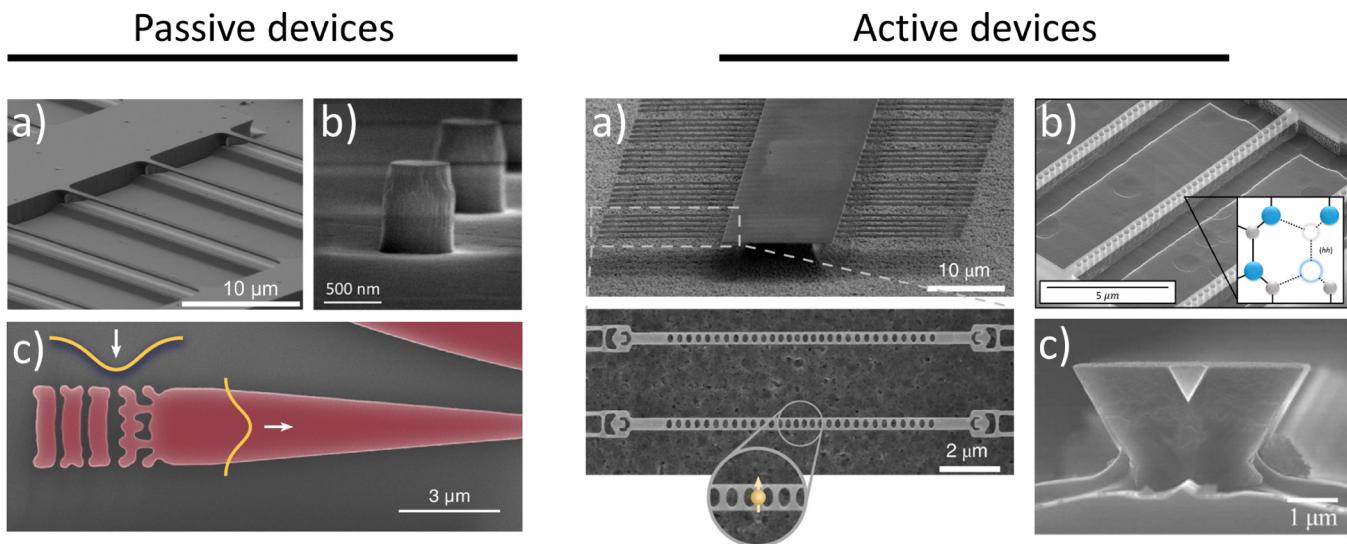


FIG. 3. The SEM images of silicon carbide photonic devices. Passive devices (clockwise from top left): (a) Triangular cross-section waveguide in 4H-SiC with integrated silicon vacancies. [Reproduced with permission from Babin *et al.*, *Nat. Mater.* **21**, 67–73 (2022). Copyright 2022, Springer Nature.] (b) Nanopillars in 4H-SiC with silicon vacancies. [Reproduced with permission from Radulaski *et al.*, *Nano Lett.* **17**(3), 1782–1786 (2017). Copyright 2017 American Chemical Society.] (c) Vertical coupler fabricated in 4H-SiCOI to convert free-space Gaussian beam into fundamental waveguide mode. [Reproduced with permission from Guidry *et al.*, *Optica* **7**, 1139–1142 (2020). Copyright The Optical Society, 2020.¹⁸⁹] Active devices: (a) Suspended nanobeam array fabricated in 4H-SiCOI and (below) magnified image of individual nanobeam PCC with integrated silicon vacancies. [Reproduced with permission from Lukin *et al.*, *Nat. Photonics* **14**, 330–334 (2020). Copyright 2020, Springer Nature.] (b) Nanobeam PCC in 4H-SiC with integrated neutral divacancies. [Reproduced with permission from Crook *et al.*, *Nano Lett.* **20**(5), 3427–3434 (2020). Copyright 2020 American Chemical Society.] (c) Triangular cross-section nanobeam PCC fabricated in 4H-SiC.¹⁰¹ [Reproduced from *Appl. Phys. Lett.* **113**, 231106 (2018), with the permission of AIP Publishing LLC.]

C. Nanofabrication methods

To build scalable QIP technologies, photonic devices need to be fabricated in a repeatable manner on chip-scale. Despite the mature nanofabrication processes in SiC, the substrate is chemically inert and difficult to etch through wet-etching methods. Dry etching methods^{109–111} used to fabricate photonic devices in SiC were not able to achieve simulated ultra-high values of Q-factor due to fabrication errors (misalignment of features), surface roughness (low Q-factor), and imperfect emitter positioning in the cavity (poor coupling between cavity and emitter). Surface passivation using epitaxial AlN was used to improve the photostability, charge state stability, and enhance the emission of carbon anti-site vacancy in 4H-SiC.¹¹²

Integration of color center photonics with other platforms starts with heteroepitaxially grown high quality single crystal thin films on silicon and silicon dioxide. The low temperature phase, 3C-SiC, which readily grows on silicon substrates was used to fabricate photonic devices.^{97,113,114} But, these 3C-SiC thin films had high densities of crystal defects due to the lattice mismatch with Si, resulting in large material absorption and degradation in color center optical properties.¹⁰³ Smart-cut method used to create SiC-on-insulator (SiCOI)¹¹⁵ is not suitable for color center photonics as the SiC layer suffered from implantation damages that are irreparable through annealing at elevated temperatures. Recently, 4H-SiCOI was produced by wafer bonding 4H-SiC on insulator (silicon dioxide) followed by grinding and polishing the SiC to

obtain high-quality thin films suitable for fabricating high performing photonic devices and color center integration.⁹² While successful in generating high-quality individual devices, this process faces challenges in achieving uniform film thickness through polishing on a wafer-scale.

Underetching of photonic structures which creates optical isolation and prevents mode leakage into the bulk was used to demonstrate PCC with high Q-factor ($>10^4$). Dopant selective photoelectrochemical etch¹¹⁶ was used to fabricate 1D nanobeam PCC with Purcell enhancement up to 80 times.^{19,95} But, this method is limited due to the requirement of specific doping profiles in SiC. Angled etching is another underetching method first demonstrated in diamond¹¹⁷ and later demonstrated in SiC.^{66,101} The triangular cross-sections resulting from the angled etching in SiC was achieved using Faraday cage method and can be done at wafer scale using ion beam etching methods used in diamond.¹¹⁸

Nanofabrication process variability results in deviation of the cavity's resonant wavelength designed to match the ZPL wavelength of the color center. The cavity can be tuned into resonance by condensing gas on the devices^{119,120} and effectively reversed by heating the chip. For a much more precise and fast tuning, the emitter can be tuned into resonance with the cavity using DC Stark effect^{121–124} and strain fields.^{125,126} Both these methods can be used to tune spatially separated emitters into mutual resonance necessary for remote entanglement. Despite advanced fabrication processes and high crystal quality, the emitters experience spectral

TABLE I. Emission parameters for NV center in diamond, and silicon vacancy (V_{Si}^-), divacancy ($V_{Si}V_C^0$), and nitrogen vacancy ($N_CV_{Si}^-$) in 4H-SiC. T_2 is the electron spin-coherence time. The highest measured electron spin-coherence times^{21,27,39,108} and DWF^{19,25,36,70} are presented. 1/e loss corresponds to the power reduction by the factor $e = 2.718$. The distance covered by the photon during T_2 is calculated by assuming a constant speed of light in the fiber (refractive index = 1.44) at all wavelengths. The target Q-factors to achieve 99% emission through the ZPL are calculated for a cavity with mode volume of $(\lambda/n)^3$ for cases of purely radiative recombination and 3:1 non-radiative to radiative decay ratio.

Defect	ZPL (nm)	DWF	T_2 (ms)	Fiber loss (dB/ km)	Propagation length in fiber (km)		Target Q-factor for $V = (\lambda/n)^3$	
					before 1/e loss	during T_2	radiative decay only	3:1 non-rad.:rad. decay
NV ⁻ (diamond)	637	3%	1.8	10	0.4	374	1.4×10^6	5.8×10^6
V_{Si}^- (4H-SiC)	861-917	6-9%	20	1.5	2.9	4,160	$(0.15 - 0.34) \times 10^6$	$(0.6 - 1.4) \times 10^6$
$V_{Si}V_C^0$ (4H-SiC)	1078-1132	5%	5300	0.8	5.4	1.1×10^6	0.5×10^6	2.1×10^6
$N_CV_{Si}^-$ (4H-SiC)	1176-1242	5%	0.017 (3C)	0.6	7.2	3.53	0.5×10^6	2.1×10^6

diffusion (broadening of optical linewidths) due to charge fluctuations in the local environment caused by surface charges, and distribution of emitters which capture and release charges. Strain generated during growth and nanofabrication of photonic devices also contributes to the degradation of optical linewidths. But this spectral diffusion/instability is an extrinsic property that can be solved either by integrating charge depletion using advanced doping epitaxy or by optimized optical excitation via time-dependent drive or optimized steady-state illumination.¹⁴ The charge state of the emitters were successfully controlled through optical illumination¹²⁷ and integration of emitters into Schottky barrier diodes.¹²⁴ Emitters integrated into the depletion region of a p-i-n diode enabled deterministic control over the charge state of the emitter^{121,128} and electrical readout of the spin state.¹²⁹ Optimal emitter distribution can be achieved using more controllable defect generation methods like focused ion beam,¹³⁰ laser writing,^{131,132} proton beam writing,¹³³ and ion implantation on patterned substrates.¹³⁴

D. External fields

Upon addressing the inhomogeneities in the color center environment through isotopic purification and integration into electronic and photonic devices, the single photon emission of a color center can be tuned by a direct application of an external interaction such as electric field, magnetic field, mechanical strain, and acoustic fields.^{13,61} The energy levels of the color center are sensitive to the applied external field, causing a split or shift of the ground and/or excited states (tuning). For QIP applications, the tuning achieved by the application of electric or strain fields should be larger than the inhomogeneous broadening (~ 10 GHz for V_{Si}^- ⁶⁶), before the material experiences any dielectric or mechanical failure.⁶¹

The splitting and shifting of energy levels due to an electric and magnetic field are called the Stark and Zeeman effect. Electric fields have been used to tune the ZPL of silicon vacancy^{122,124} and divacancy^{121,123} in 4H-SiC by up to 60 GHz and 800 GHz, respectively. In another take, a magnetic field applied along the c-axis of

4H-SiC was used to suppress the parasitic spin mixing of silicon vacancy, to achieve controlled generation of indistinguishable photons.²⁸ Strain that is applied externally or formed intrinsically during crystal growth can result in tuning of the emission wavelength of color centers. Moreover, the density-functional theory predicts that silicon vacancy²⁵ and divacancy^{135,136} in SiC produce larger ZPL shifts under strain fields than electric fields.¹²¹⁻¹²⁴ Silicon vacancy in 6H-SiC has been shown to exhibit strain-induced ZPL shifts up to 6 THz.^{137,138} In an engineered acoustic device, the coupling of spin to strain was demonstrated for divacancy in SiC.¹³⁹ This shows that the engineering toolbox has multiple methods to counter the inhomogeneous broadening of color center emission at or beyond the required magnitudes.

IV. QUANTUM INFORMATION HARDWARE APPLICATIONS

In this section, we discuss methods of employing color centers for applications in quantum networking, simulation, and computing.

A. Quantum repeaters

In classical communication, the loss experienced by the signal (photons) propagating in the fiber is compensated through its amplification at intermediate points in the channel, thus enabling long-distance communication. In the quantum domain, communication over long distances cannot be implemented in such a fashion due to the consequences of the no-cloning theorem. In addition to the fiber losses (which scale exponentially with distance between entangled links), the photons in the quantum communication channel also experience depolarization losses. A long range entanglement can be generated using quantum repeater (QR) schemes which involve dividing the communication channel into smaller segments connected by the QR stations, followed by establishing entanglement between the ends of each of the segments. Then, the desired long range entanglement is generated by performing entanglement swapping of the entangled states of each segment.

The QR stations are designed to perform some (or all) of the following three tasks: heralded entanglement generation (HEG) for correcting loss errors, heralded entanglement purification (HEP) to correct for operation errors (from measurements and gate operations), and entanglement swapping to extend the entanglement. Entanglement (HEG) is generated between color centers in two remote QR stations by first creating spin-photon entanglement locally, followed by interference of the photons on a beam splitter to create spin–spin entanglement,^{65,86,140} as shown in Fig. 4. HEP using color centers begins with swapping a low-fidelity electron spin–spin entanglement onto nuclear spins (memory qubits), followed by another cycle of HEG (low-fidelity), and finally local gate operations are performed on the electron and nuclear spin in each QR station to generate a higher fidelity entanglement link.^{141,142}

The heralding involves two-way signaling between QR stations to verify the success of entanglement/purification, which requires long-lived quantum memories¹⁴³ and determines the achievable communication rates. Instead, quantum error correction (QEC) can be used to overcome the loss and operation errors deterministically, requiring one-way signaling. Depending on the approach for overcoming losses, quantum repeaters can be classified into three generations, each offering improved communication rates over implementations without quantum repeaters, which follows an inverse exponential scaling with the total distance between the ends of the network.

The first generation QRs overcomes loss and operation errors through HEG and HEP, respectively. The communication rate (1 Hz range) is limited by the two-way signaling and would require quantum memories with milliseconds or higher coherence times for longer distances (>1000 km), even for optimized protocols.¹⁴⁴ The second generation QRs, like the first one, overcomes loss through HEG but uses QEC on encoded qubits^{6,67,145} to rectify operation errors. The communication rate (kHz range) depends on the time needed for two-way signaling between adjacent QR stations and local gate operations, relaxing the long coherence time requirement for memory qubits. The third generation QRs uses QEC for overcoming both loss and operation errors.^{146–148} Since two-way signaling is not involved in this generation, the communication rates depend on the local gate operation times, achieving rates (MHz) close to the classical repeaters. However, this generation suffers from low tolerance to matter-photon coupling losses ($\leq 10\%$) even with hundreds of qubits per repeater station.¹⁴⁸

The successful implementation of the different QR generations depends on the various parameters of the technological building blocks in their architecture. This includes the fidelity and operation time of the gates performing local operations, as well as the coupling efficiency (emission of photons from matter qubits, coupling of photons into the fiber, coupling between photons and matter qubits, detection efficiency). Cost function¹⁴⁸ analysis shows that (a) high gate error probability ($\geq 1\%$) is more suited for the first generation QRs, (b) low/intermediate gate error probability ($\leq 1\%$), low coupling efficiency ($\leq 90\%$), and slow gate operation ($\geq 1\mu\text{s}$) benefit the second generation QRs, and (c) low gate error probability ($\leq 1\%$), high coupling efficiency ($\geq 90\%$), and fast gate operation ($\leq 1\mu\text{s}$) favors the third generation QRs.¹⁴⁹

Color center systems in SiC used to demonstrate HEG^{65,86} are suitable for implementation of the first and the second generation

of QRs. Their potential for long-distance emission propagation and the technological requirements for highly indistinguishable photon generation are analyzed in Table I. Spectral inhomogeneity of disparate emitters can be improved by (1) minimizing spectral diffusion through optical illumination¹²⁷ and integration of color centers into Schottky,¹²⁴ p-i-n^{121,128} diodes, and (2) Emission tuning through the application of electric field^{121–124} and strain.^{25,135–138} Isotopic purification and dynamical decoupling should be employed to assure long spin-coherence times. Color centers with higher spin-coherence times (seconds range) can be used to implement the first generation QRs for longer distances (≥ 1000 km). The emission rates can be improved by efficient integration of color centers into nanophotonic devices through Purcell effect. As discussed in the previous section, nanophotonic integration can be further improved through triangular cross-section devices, optimal positioning of color center in the cavity, and improved nanofabrication to reduce scattering losses. Efficient nanophotonic integration also boosts the spin-photon coupling efficiency necessary for implementation of the third generation QRs. To complete the tool set, the HEP obtained with NV center in diamond¹⁴¹ is yet to be demonstrated using SiC color centers.

Critical steps in the implementation of entanglement protocols like high-fidelity spin state initialization and resonant readout,^{20,65} single-shot readout via spin-to-charge conversion,²¹ and high-fidelity nuclear spin initialization^{65,150} were demonstrated using neutral divacancies in SiC. Despite the low DWF of divacancy ($\sim 5\%$), single-shot readout measurements can be pursued through efficient cavity integration.¹⁹ Silicon vacancy has a strong intersystem crossing which allows for high-fidelity spin initialization,³⁰ but also prevents high-fidelity readout.¹⁵¹ Here too, integration into a nanocavity with moderate Purcell factor of less than 100, can result in photon counts sufficient to achieve quantum non-demolition readout of the spin state.³⁰ Efficient quantum frequency conversion of emission from divacancy and silicon vacancy to the telecommunication band should be developed to extend the range of quantum communication. Integration of SNSPDs onto photonic devices would boost the success rates of the measurement protocols.^{56,57} Other potential color centers that need to be studied closely are the ones with emission in telecommunication band (NV[–], V⁴⁺, Er³⁺) to minimize the fiber losses, and those with large DWF (Cr⁴⁺, V⁴⁺) that offer high photon counts for single-shot readout. It should be noted that the current state-of-the-art performance of color centers in SiC (especially divacancy) are more promising than the NV center in diamond for QIP applications. SiC photonic devices require lower Q-factors for achieving high photon counts and their color center's ZPL photons propagate for much longer distances in fiber, as shown in Table I.

The demanding requirements on the matter qubits for the implementation of quantum repeaters presents an opportunity for an all-photonic quantum repeater scheme implemented using single-photon sources, linear optical elements, photon detectors, and optical switches.¹⁵² Realization of the highly entangled states known as graph states [Fig. 6(a)] are needed to implement an all-photonic measurement-based quantum repeaters.^{153,154} A photonic cluster state can be generated by continuous optical pumping of a single photon emitter to produce a chain of photons that are entangled with other photons and the emitter.¹⁵⁵ Assuming millisecond spin coherence and nanosecond optical lifetime, a back of the envelope

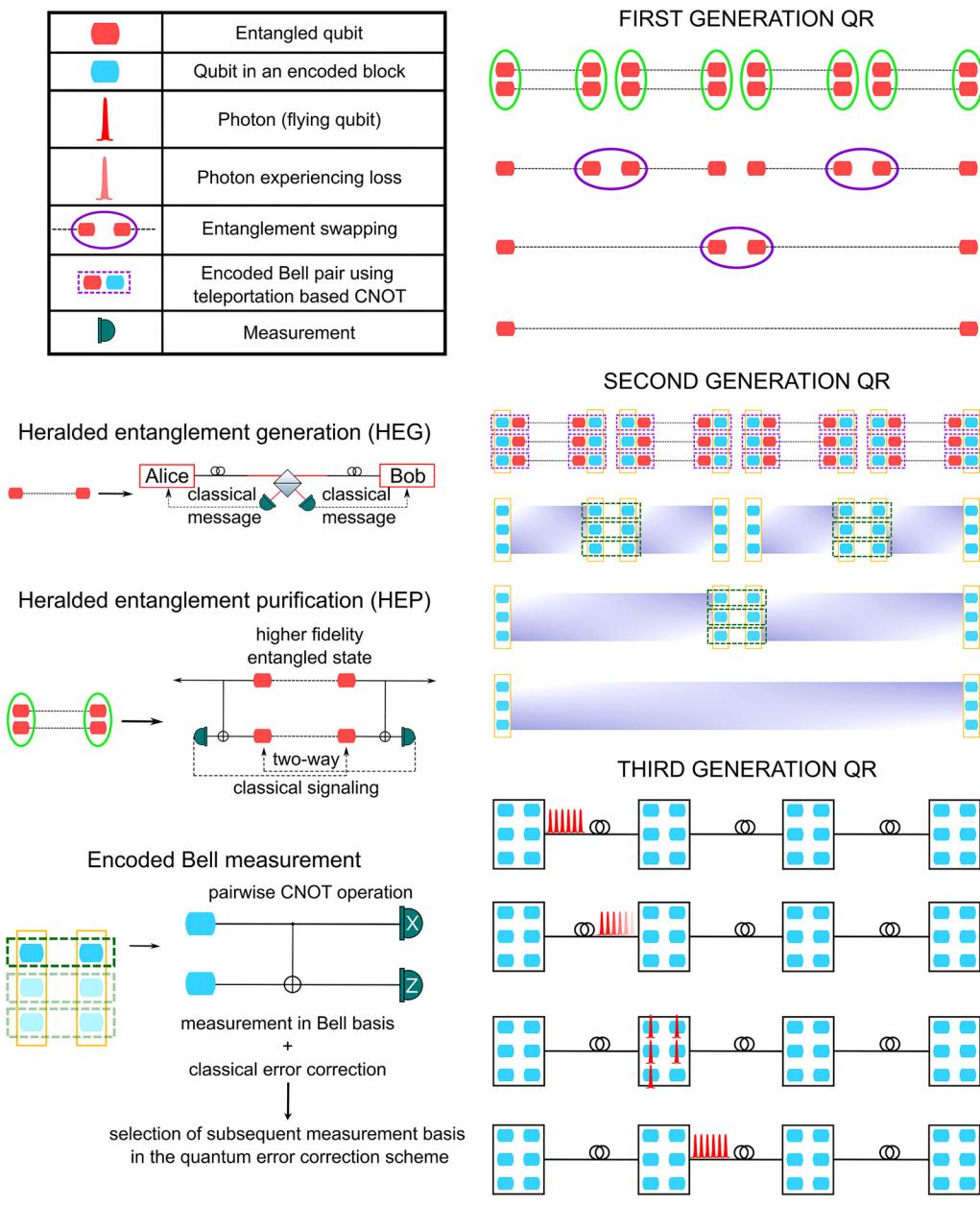


FIG. 4. The entanglement schemes designed in the three generations of quantum repeaters as a guide for SiC quantum information processing.^{1,5–7,67,145–148}

calculation would predict cluster states of the order of 10^6 photons. However, to make this estimate more realistic to experimental conditions, the effects of non-radiative recombination and photon collection would need to be considered. These reductions could be made up for by Purcell enhancement in nanocavities. Approaches for generating large clusters of entangled photons for divacancy, silicon vacancy, and NV center in SiC have been proposed.¹⁵⁶ To deterministically generate cluster states that outperform matter qubit based

QRs, very high fidelity and fast entangling gates, and high photon generation and collection rates will be required.¹⁵⁷

B. Quantum simulation

The idea of quantum information systems as models for quantum materials simulation has been around since the first quantum computing proposals. While a quantum advantage in

simulation has not yet been demonstrated, with advancements in emitter integration into nanocavities, these nanophotonic systems are progressing toward versatile cavity quantum electrodynamical (CQED) platforms. Coupled cavity arrays with integrated emitters, as illustrated in Fig. 5, have been of special interest for all-photonic quantum simulation. The modeling of such systems has shown their representation potential for the dynamics of complex condensed matter phases such as charge density waves, supersolidity, and the quantum phase transitions between the superfluid and Mott insulator phases.^{158,159} CQED-based quantum information frameworks primarily rely on the strong light and matter interaction, where the photon loss rates from the cavity and emitter, κ and γ , respectively, are less than twice the emitter-cavity coupling strength, g , which is related to the DWF by

$$g = \sqrt{\frac{3\pi c^3 \xi}{2\tau\omega^2 n^2 V}},$$

where τ is the lifetime of the emitter, V is the cavity mode volume, and ξ is the DWF.¹⁶⁰ The strong coupling regime has been demonstrated in systems like single atoms in Fabry-Pérot cavities, single quantum dots in solid-state cavities, and in superconducting Josephson junction systems,^{161–164} however, each of these systems has at least one fundamental drawback. Atom-Fabry-Pérot systems can be difficult to scale up to the size that more complex quantum information systems require. Quantum dots, as mesoscopic objects, can have a relatively wide distribution of emission wavelengths even when fabricated by the same process. Superconducting Josephson junction systems operate at millimeter wavelengths which are not compatible with distributed QIP.

While much progress has been made to make up for these various difficulties, SiC color centers in nanophotonic cavities inherently address all these issues. First, color centers are scalable via integration into devices, as detailed in Sec. III. Second, the linewidths of zero-phonon lines of color centers are generally much smaller than those of quantum dots. Finally, the near-infrared emission wavelengths provide some flexibility in the fabrication of

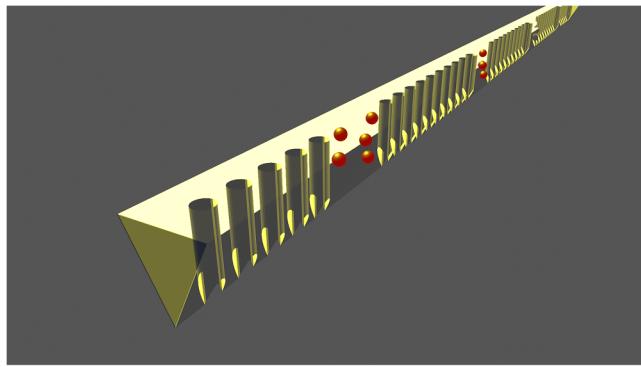


FIG. 5. An illustration of an all-photonic quantum simulator that could be implemented in a triangular SiC coupled cavity array with integrated color centers.^{165,166}

scalable cavity arrays, since the features do not need to be as small as in the case of diamond emitters. This is not to imply that bringing color center systems into strong coupling CQED systems is devoid of challenges. The current state-of-the-art in color center-based nanophotonics is stymied by the low DWF and the presence of non-radiative recombination, which adds difficulty to achieving strong light-matter interaction in such systems. With careful nanodevice design, it is possible to modify ξ , τ , and V as discussed in Sec. III. However, there has also been significant work in investigating multiple color centers acting as an ensemble, which scales the light-matter interaction strength by \sqrt{N} , where N is the number of emitters in the ensemble, to achieve strong coupling and demonstrate polaritonic physics.^{165–168}

C. Measurement-based quantum computing

One of the major goals of QIP is building a fully scalable quantum computer that can execute arbitrary quantum algorithms and distribute complex computations. With this motivation, the measurement-based quantum computer (MQC),^{169,170} also known as the one-way quantum computer, was proposed as an alternative to the more established circuit model. The universal resource for MQC is a highly entangled state known as the cluster state [Fig. 6(a)]. Any sequential quantum circuit can be imprinted on the cluster state with only single qubit measurements. The standard procedure for cluster state generation is divided into two steps: (i) prepare all qubits in the $|+\rangle = (|0\rangle + |1\rangle)/\sqrt{2}$ state (in the Pauli Z computational basis), and (ii) implement Ising-type next-neighbor interaction by applying the control-Z (entangling) gates between each pair of qubits. With each computational step, the entanglement is consumed by the subsequent measurement of qubits in a certain direction. Cluster state provides MQC with multiple advantages over the circuit-based model including decomposing large computational space into steps by re-utilizing the cluster,¹⁶⁹ concatenation of gate simulations,¹⁷⁰ distributed,^{171–173} loss-tolerant,^{174,175} and fault-tolerant^{176,177} quantum computation. Apart from MQC, the cluster state remains an efficient resource for quantum repeaters, as discussed previously.

Due to long coherence times and ease of manipulation of photons, optical quantum computing with cluster states¹⁷⁸ emerged from the combination of linear optics quantum computation (popularly known as the KLM scheme)¹⁷⁹ and MQC.¹⁶⁹ Using photons to produce highly entangled graph states is difficult, as photons naturally do not interact with each other. In earlier times, photonic graph states were generated either by measurement-induced entanglement¹⁸⁰ (with cavities and multiplexer¹⁸¹) or by spontaneous parametric down-conversion (SPDC) combined with the so-called fusion gates.¹⁸² As their generation depended on the probabilistic photodetection process, photonic graph states have reached experimental size of only ten photons¹⁸³ with this approach. Deterministic generation of 1D photonic cluster strings was first realized by the Lindner-Rudolph protocol¹⁸⁴ from quantum dots with specific level structure and selection rules. Although 1D graph state suffices for quantum repeaters, the universal quantum computation requires a 2D graph state. This need was met in a proposal suggesting the use of entangled photons from entangled quantum emitters.¹⁸⁵ Basing on this idea, subsequent protocols^{155,186–188}

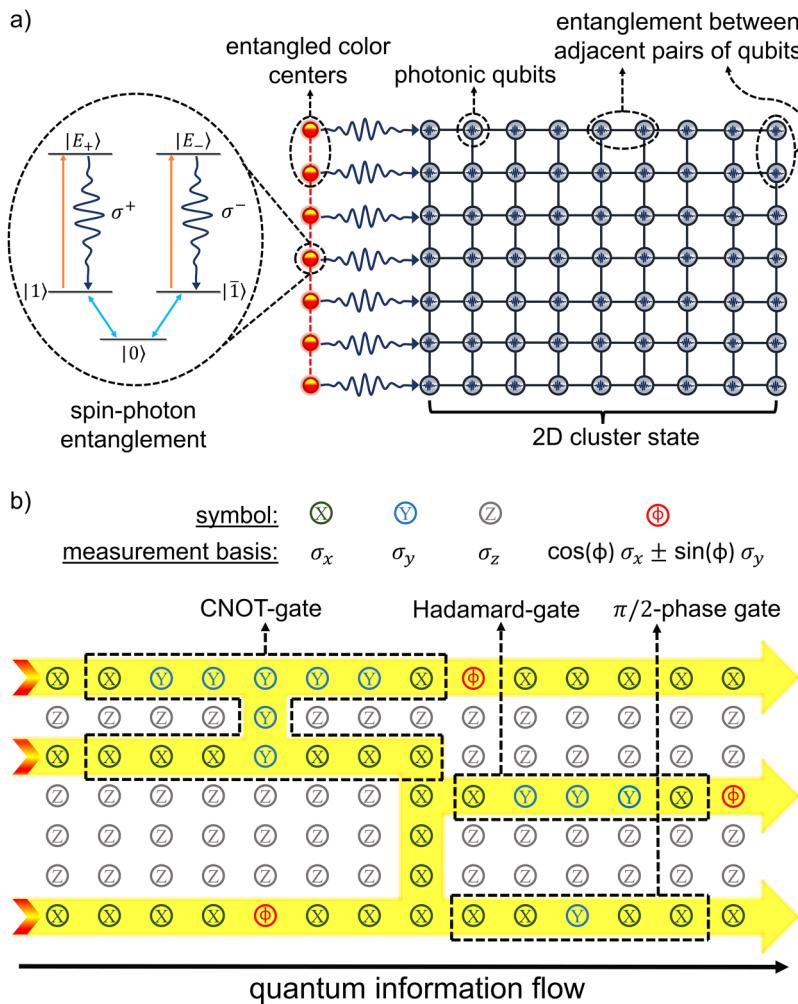


FIG. 6. Color center implementation of all optical quantum computation with cluster states. (a) Generation of the photonic cluster state using repeated emissions from entangled color centers. Inset figure shows the so-called I-I energy level structure for spin-photon entanglement creation, exhibited in spin- $\frac{3}{2}$ and spin-1 emitters in SiC, such as silicon vacancy, divacancy, and NV center.¹⁵⁶ (b) Quantum logic network implemented on the cluster state via single qubit measurements in different bases.^{169,170} Operating principles are detailed in the main text.

have been developed for generating arbitrarily large photonic graph states from solid-state emitters such as trapped ions, quantum dots, and NV centers in diamond. The protocol for 2D cluster state generation from NV centers in diamond¹⁸⁸ requires only microwave pulses (for emitter manipulation), optical pumping (for photon generation), and waveplate and polarization photon counters (for measurement) to implement MQC, thus making it suitable for implementation with SiC color center photonics.

Although the silicon carbide protocols have been studied only in terms of 1D photonic cluster state generation,¹⁵⁶ the field can benefit from the wide pool of studies in diamond NV center with whom divacancies and NV centers in SiC share similar electronic structure and selection rules. As a result, protocol for 2D photonic cluster state generation from NV centers in diamond¹⁸⁸ can be directly implemented in divacancies and NV centers in SiC. Figure 6 manifests a perspective on MQC with SiC color centers. First, a highly entangled $n \times m$ cluster state is generated from entangled color centers, where n is the number of color centers and m is the number of pump cycles [Fig. 6(a)]. In the inset, the energy level structures of divacancy and

NV center in SiC are shown. With zero magnetic field, the ground $|\pm 1\rangle$ and excited $|E_{\pm}\rangle$ states are degenerate but do not mix. Each ground state couples to one excited state with spontaneous emission of light having opposite circular polarization (σ^{\pm}) which generates spin-photon entanglement, while the $|0\rangle$ acts as an auxiliary state. Individual color centers can be entangled with each other via protocols involving electron and nuclear spin entanglement.¹⁸⁸ After 2D cluster state generation, a quantum logic network is implemented on the cluster state with single qubit measurements [Fig. 6(b)]. A σ_x measurement acts like a *wire* between adjacent pairs of qubits, a σ_y measurement removes the qubit from linear cluster but links the neighboring qubits which simultaneously makes it work like a *wire*, and a σ_z measurement removes the qubit from the rest of the cluster state. Measurements in the $\cos(\phi)\sigma_x \pm \sin(\phi)\sigma_y$ basis are performed in order to realize arbitrary rotations to compensate for the randomness in rotations due to Pauli observables. However, in a more general sense, the measurement basis depends on the preceding measurements, which imposes a temporal order for a particular quantum logic implementation in a certain direction.^{169,170}

To implement these MQC protocols in color centers, the main challenge is to apply entangling gates to generate the 2D cluster state and do at least one round of measurement before the spin decoheres. Assuming $30\ \mu\text{s}$ time to apply entangling gates with high fidelity ($\geq 99\%$), as seen in diamond NV center,¹⁸⁶ this puts the lower limit on the required coherence time to hundreds of microseconds. This timescale makes divacancy and silicon vacancy in SiC currently the best suited candidates for SiC-based MQC, as they have spin coherence times in the milliseconds-seconds range^{66,83} (see Table 1). Experimental challenges such as spontaneous emission rate and inefficient photon collection due to low ZPL emission, and photon loss during multi-emitter entanglement also impede deterministic cluster state generation from realization in color centers.^{155,156,186,188} These issues can be resolved by coupling SiC color centers to a photonic crystal cavity that extends into a single-mode waveguide attached to a detector [see Fig. 2(a)], fiber or an efficient grating coupler.^{66,92,95,165} Therefore, integrated SiC photonics has the potential to be a rich toolbox for full-fledged execution of MQC.

V. SUMMARY

In this Perspective, we have presented integrated silicon carbide photonics as a powerful playground for quantum technology development. Although SiC has benefits as a material platform for QIP applications like CMOS compatible, wafer-scale nanofabrication processes and availability of color centers with emission in telecommunication wavelength, progress needs to be made in the realm of entanglement generation in integrated color center devices.

In an international and interdisciplinary scientific effort, this field is moving to demonstrate unique capabilities in materials engineering, spin-photon entanglement, and cavity-emitter interaction. The potential impact on quantum networking, simulation, and computing has been drawing a larger community to explore SiC color centers, and we hope this paper will serve as a guiding material to connect concepts from related fields.

ACKNOWLEDGMENTS

This work was supported by the National Science Foundation (NSF) (No. CAREER-2047564) and the UC Davis Summer GSR Award for Engineering or Computer-related Applications and Methods.

AUTHOR DECLARATIONS

Conflict of Interest

The authors have no conflicts to disclose.

DATA AVAILABILITY

Data sharing is not applicable to this article as no new data were created or analyzed in this study.

REFERENCES

- ¹B. Hensen, H. Bernien, A. E. Dréau, A. Reiserer, N. Kalb, M. S. Blok, J. Ruitenberg, R. F. L. Vermeulen, R. N. Schouten, C. Abellán *et al.*, “Loophole-free bell inequality violation using electron spins separated by 1.3 kilometers,” *Nature* **526**(7575), 682–686 (2015).
- ²R. Stockill, M. J. Stanley, L. Huthmacher, E. Clarke, M. Hugues, A. J. Miller, C. Matthiesen, C. L. Gall, and M. Atatüre, “Phase-tuned entangled state generation between distant spin qubits,” *Phys. Rev. Lett.* **119**(1), 010503 (2017).
- ³N. Tomm, A. Javadi, N. O. Antoniadis, D. Najar, M. C. Löbl, A. R. Korsch, R. Schott, S. R. Valentín, A. D. Wieck, A. Ludwig *et al.*, “A bright and fast source of coherent single photons,” *Nat. Nanotechnol.* **16**(4), 399–403 (2021).
- ⁴H. Bernien, B. Hensen, W. Pfaff, G. Koolstra, M. S. Blok, L. Robledo, T. H. Taminiau, M. Markham, D. J. Twitchen, L. Childress *et al.*, “Heralded entanglement between solid-state qubits separated by three metres,” *Nature* **497**(7447), 86–90 (2013).
- ⁵M. Pompili, S. L. N. Hermans, S. Baier, H. K. C. Beukers, P. C. Humphreys, R. N. Schouten, R. F. L. Vermeulen, M. J. Tiggelman, L. dos Santos Martins, B. Dirkse *et al.*, “Realization of a multinode quantum network of remote solid-state qubits,” *Science* **372**(6539), 259–264 (2021).
- ⁶M. H. Abobeih, Y. Wang, J. Randall, S. J. H. Loenen, C. E. Bradley, M. Markham, D. J. Twitchen, B. M. Terhal, and T. H. Taminiau, “Fault-tolerant operation of a logical qubit in a diamond quantum processor,” *arXiv:2108.01646* (2021).
- ⁷M. K. Bhaskar, R. Riedinger, B. Machielse, D. S. Levonian, C. T. Nguyen, E. N. Knall, H. Park, D. Englund, M. Lončar, D. D. Sukachev *et al.*, “Experimental demonstration of memory-enhanced quantum communication,” *Nature* **580**(7801), 60–64 (2020).
- ⁸C. E. Bradley, J. Randall, M. H. Abobeih, R. C. Berrevoets, M. J. Degen, M. A. Bakker, M. Markham, D. J. Twitchen, and T. H. Taminiau, “A ten-qubit solid-state spin register with quantum memory up to one minute,” *Phys. Rev. X* **9**(3), 031045 (2019).
- ⁹V. A. Norman, S. Majety, Z. Wang, W. H. Casey, N. Curro, and M. Radulaski, “Novel color center platforms enabling fundamental scientific discovery,” *InfoMat* **3**(8), 869–890 (2021).
- ¹⁰N. T. Son, C. P. Anderson, A. Bourassa, K. C. Miao, C. Babin, M. Widmann, M. Niethammer, J. U-Hassan, N. Morioka, I. G. Ivanov *et al.*, “Developing silicon carbide for quantum spintronics,” *Appl. Phys. Lett.* **116**(19), 190501 (2020).
- ¹¹S. Castelletto and A. Boretti, “Silicon carbide color centers for quantum applications,” *J. Phys.* **2**(2), 022001 (2020).
- ¹²G. Zhang, Y. Cheng, J.-P. Chou, and A. Gali, “Material platforms for defect qubits and single-photon emitters,” *Appl. Phys. Rev.* **7**(3), 031308 (2020).
- ¹³M. E. Batten and L. Vines, “Manipulating single-photon emission from point defects in diamond and silicon carbide,” *Adv. Quant. Technol.* **4**, 2100003 (2021).
- ¹⁴D. M. Lukin, M. A. Gudry, and J. Vučković, “Integrated quantum photonics with silicon carbide: Challenges and prospects,” *PRX Quant.* **1**(2), 020102 (2020).
- ¹⁵M. Gurfinkel, S. Potbhare, H. D. Xiong, J. S. Suehle, Y. Shapira, A. J. Lelis, D. Habersat, and N. Goldsman, “Ion implantation and SiC transistor performance,” *J. Appl. Phys.* **105**(8), 084511 (2009).
- ¹⁶T. Staudacher, F. Ziem, L. Häussler, R. Stöhr, S. Steinert, F. Reinhard, J. Scharpf, A. Denisenko, and J. Wrachtrup, “Enhancing the spin properties of shallow implanted nitrogen vacancy centers in diamond by epitaxial overgrowth,” *Appl. Phys. Lett.* **101**(21), 212401 (2012).
- ¹⁷A. E. Rugar, H. Lu, C. Dory, S. Sun, P. J. McQuade, Z.-X. Shen, N. A. Melosh, and J. Vuckovic, “Generation of tin-vacancy centers in diamond via shallow ion implantation and subsequent diamond overgrowth,” *Nano Lett.* **20**(3), 1614–1619 (2020).
- ¹⁸W. F. Koehl, B. B. Buckley, F. J. Heremans, G. Calusine, and D. D. Awschalom, “Room temperature coherent control of defect spin qubits in silicon carbide,” *Nature* **479**(7371), 84–87 (2011).
- ¹⁹A. L. Crook, C. P. Anderson, K. C. Miao, A. Bourassa, H. Lee, S. L. Bayliss, D. O. Bracher, X. Zhang, H. Abe, T. Ohshima *et al.*, “Purcell enhancement of a single silicon carbide color center with coherent spin control,” *Nano Lett.* **20**(5), 3427–3434 (2020).

²⁰D. J. Christle, P. V. Klimov, F. Charles, K. Szász, V. Ivády, V. Jokubavicius, J. U-Hassan, M. Syväjärvi, W. F. Koehl, T. Ohshima *et al.*, “Isolated spin qubits in SiC with a high-fidelity infrared spin-to-photon interface,” *Phys. Rev. X* **7**(2), 021046 (2017).

²¹C. P. Anderson, E. O. Glen, C. Zeledon, A. Bourassa, Y. Jin, Y. Zhu, C. Vorwerk, A. L. Crook, H. Abe, J. Ul-Hassan *et al.*, “Five-second coherence of a single spin with single-shot readout in silicon carbide,” [arXiv:2110.01590](https://arxiv.org/abs/2110.01590) (2021).

²²J. S. Pelc, C. Langrock, Q. Zhang, and M. M. Fejer, “Influence of domain disorder on parametric noise in quasi-phase-matched quantum frequency converters,” *Opt. Lett.* **35**(16), 2804–2806 (2010).

²³E. Sörman, N. T. Son, W. M. Chen, O. Kordova, C. Hallin, and E. Janzén, “Silicon vacancy related defect in 4H and 6H SiC,” *Phys. Rev. B* **61**(4), 2613 (2000).

²⁴E. Janzén, A. Gali, P. Carlsson, A. Gällström, B. Magnusson, and N. T. Son, “The silicon vacancy in SiC,” *Phys. B* **404**(22), 4354–4358 (2009).

²⁵P. Udvarhelyi, G. Thiering, N. Morioka, C. Babin, F. Kaiser, D. Lukin, T. Ohshima, J. Ul-Hassan, N. T. Son, J. Vučković *et al.*, “Vibronic states and their effect on the temperature and strain dependence of silicon-vacancy qubits in 4H-SiC,” *Phys. Rev. Appl.* **13**(5), 054017 (2020).

²⁶R. Nagy, M. Widmann, M. Niethammer, D. B. R. Dasari, I. Gerhardt, Ö. O. Soykal, M. Radulaski, T. Ohshima, J. Vučković, N. T. Son *et al.*, “Quantum properties of dichroic silicon vacancies in silicon carbide,” *Phys. Rev. Appl.* **9**(3), 034022 (2018).

²⁷D. Simin, H. Kraus, A. Sperlich, T. Ohshima, G. V. Astakhov, and V. Dyakonov, “Locking of electron spin coherence above 20 ms in natural silicon carbide,” *Phys. Rev. B* **95**(16), 161201 (2017).

²⁸N. Morioka, C. Babin, R. Nagy, I. Gediz, E. Hesselmeier, D. Liu, M. Joliffe, M. Niethammer, D. Dasari, V. Vorobyov *et al.*, “Spin-controlled generation of indistinguishable and distinguishable photons from silicon vacancy centres in silicon carbide,” *Nat. Commun.* **11**(1), 1–8 (2020).

²⁹W. Dong, M. W. Doherty, and S. E. Economou, “Spin polarization through intersystem crossing in the silicon vacancy of silicon carbide,” *Phys. Rev. B* **99**(18), 184102 (2019).

³⁰R. Nagy, M. Niethammer, M. Widmann, Y.-C. Chen, P. Udvarhelyi, C. Bonato, J. Ul-Hassan, R. Karhu, I. G. Ivanov, N. T. Son *et al.*, “High-fidelity spin and optical control of single silicon-vacancy centres in silicon carbide,” *Nat. Commun.* **10**(1), 1–8 (2019).

³¹V. A. Soltamov, B. V. Yavkin, D. O. Tolmachev, R. A. Babunts, A. G. Badalyan, V. Y. Davydov, E. N. Mokhov, I. I. Proskuryakov, S. B. Orlinskii, and P. G. Baranov, “Optically addressable silicon vacancy-related spin centers in rhombic silicon carbide with high breakdown characteristics and endor evidence of their structure,” *Phys. Rev. Lett.* **115**(24), 247602 (2015).

³²P. Udvarhelyi, R. Nagy, F. Kaiser, S.-Y. Lee, J. Wrachtrup, and A. Gali, “Spectrally stable defect qubits with no inversion symmetry for robust spin-to-photon interface,” *Phys. Rev. Appl.* **11**(4), 044022 (2019).

³³R. Nagy, D. B. R. Dasari, C. Babin, D. Liu, V. Vorobyov, M. Niethammer, M. Widmann, T. Linkewitz, I. Gediz, R. Stöhr *et al.*, “Narrow inhomogeneous distribution of spin-active emitters in silicon carbide,” *Appl. Phys. Lett.* **118**(14), 144003 (2021).

³⁴S. A. Zargaleh, B. Eble, S. Hameau, J.-L. Cantin, L. Legrand, M. Bernard, F. Margallan, J.-S. Lauret, J.-F. Roch, H. J. Von Bardeleben *et al.*, “Evidence for near-infrared photoluminescence of nitrogen vacancy centers in 4H-SiC,” *Phys. Rev. B* **94**(6), 060102 (2016).

³⁵H. J. Von Bardeleben, J. L. Cantin, E. Rauls, and U. Gerstmänn, “Identification and magneto-optical properties of the nv center in 4H-SiC,” *Phys. Rev. B* **92**(6), 064104 (2015).

³⁶S. A. Zargaleh, S. Hameau, B. Eble, F. Margallan, H. J. von Bardeleben, J.-L. Cantin, and W. Gao, “Nitrogen vacancy center in cubic silicon carbide: A promising qubit in the 1.5 μ m spectral range for photonic quantum networks,” *Phys. Rev. B* **98**(16), 165203 (2018).

³⁷K. Khazen, H. J. Von Bardeleben, S. A. Zargaleh, J. L. Cantin, M. Zhao, W. Gao, T. Biktagiroy, and U. Gerstmänn, “High-resolution resonant excitation of NV centers in 6H-SiC: A matrix for quantum technology applications,” *Phys. Rev. B* **100**(20), 205202 (2019).

³⁸H. J. von Bardeleben, J.-L. Cantin, U. Gerstmänn, W. G. Schmidt, and T. Biktagiroy, “Spin polarization, electron-phonon coupling, and zero-phonon line of the NV center in 3C-SiC,” *Nano Lett.* **21**(19), 8119–8125 (2021).

³⁹J.-F. Wang, F.-F. Yan, Q. Li, Z.-H. Liu, H. Liu, G.-P. Guo, L.-P. Guo, X. Zhou, J.-M. Cui, J. Wang *et al.*, “Coherent control of nitrogen-vacancy center spins in silicon carbide at room temperature,” *Phys. Rev. Lett.* **124**(22), 223601 (2020).

⁴⁰J.-F. Wang, Z.-H. Liu, F.-F. Yan, Q. Li, X.-G. Yang, L. Guo, X. Zhou, W. Huang, J.-S. Xu, C.-F. Li *et al.*, “Experimental optical properties of single nitrogen vacancy centers in silicon carbide at room temperature,” *ACS Photonics* **7**(7), 1611–1616 (2020).

⁴¹N. T. Son, A. Ellison, B. Magnusson, M. F. MacMillan, W. M. Chen, B. Monemar, and E. Janzén, “Photoluminescence and zeeman effect in chromium-doped 4H and 6H SiC,” *J. Appl. Phys.* **86**(8), 4348–4353 (1999).

⁴²W. F. Koehl, B. Diler, S. J. Whiteley, A. Bourassa, N. T. Son, E. Janzén, and D. D. Awschalom, “Resonant optical spectroscopy and coherent control of Cr⁴⁺ spin ensembles in SiC and GaN,” *Phys. Rev. B* **95**(3), 035207 (2017).

⁴³B. Diler, S. J. Whiteley, C. P. Anderson, G. Wolfowicz, M. E. Wesson, E. S. Bielejec, F. J. Heremans, and D. D. Awschalom, “Coherent control and high-fidelity readout of chromium ions in commercial silicon carbide,” *npj Quant. Information* **6**(1), 1–6 (2020).

⁴⁴L. Spindlberger, A. Csöré, G. Thiering, S. Putz, R. Karhu, J. Ul-Hassan, N. T. Son, T. Fromherz, A. Gali, and M. Trupke, “Optical properties of vanadium in 4H silicon carbide for quantum technology,” *Phys. Rev. Appl.* **12**(1), 014015 (2019).

⁴⁵G. Wolfowicz, C. P. Anderson, B. Diler, O. G. Poluektov, F. Joseph Heremans, and D. D. Awschalom, “Vanadium spin qubits as telecom quantum emitters in silicon carbide,” *Sci. Adv.*, **6**(18):eaaz1192, 2020.

⁴⁶A. Gällström, B. Magnusson, and E. Janzén, “Optical identification of Mo related deep level defect in 4H and 6H SiC,” in *Materials Science Forum* (Trans Tech Publ, 2009), Vol. 615, pp. 405–408.

⁴⁷T. Bosma, G. J. J. Lof, C. M. Gilardoni, O. V. Zwier, F. Hendriks, B. Magnusson, A. Ellison, A. Gällström, I. G. Ivanov, N. T. Son *et al.*, “Identification and tunable optical coherent control of transition-metal spins in silicon carbide,” *npj Quant. Information* **4**(1), 1–7 (2018).

⁴⁸C. M. Gilardoni, T. Bosma, D. van Hien, F. Hendriks, B. Magnusson, A. Ellison, I. G. Ivanov, N. T. Son, and C. H. van der Wal, “Spin-relaxation times exceeding seconds for color centers with strong spin-orbit coupling in SiC,” *New J. Phys.* **22**(10), 103051 (2020).

⁴⁹A. Gällström, B. Magnusson, F. C. Beyer, A. Gali, N. T. Son, S. Leone, I. G. Ivanov, C. G. Hemmingsson, A. Henry, and E. Janzén, “Optical identification and electronic configuration of tungsten in 4H-and 6H-SiC,” *Phys. B* **407**(10), 1462–1466 (2012).

⁵⁰N. Tabassum, V. Nikas, A. E. Kaloyerous, V. Kaushik, E. Crawford, M. Huang, and S. Gallis, “Engineered telecom emission and controlled positioning of Er³⁺ enabled by SiC nanophotonic structures,” *Nanophotonics* **9**(6), 1425–1437 (2020).

⁵¹R. A. Parker, N. Dotschuk, S.-I. Sato, C. T.-K. Lew, P. Reineck, A. Nadarajah, T. Ohshima, B. C. Gibson, S. Castelletto, J. C. McCallum *et al.*, “Infrared erbium photoluminescence enhancement in silicon carbide nano-pillars,” *J. Appl. Phys.* **130**(14), 145101 (2021).

⁵²I. Aharonovich, D. Englund, and M. Toth, “Solid-state single-photon emitters,” *Nat. Photonics* **10**(10), 631–641 (2016).

⁵³M. J. Stevens, S. Glancy, S. W. Nam, and R. P. Mirin, “Third-order antibunching from an imperfect single-photon source,” *Opt. Express* **22**(3), 3244–3260 (2014).

⁵⁴A. Rundquist, M. Bajcsy, A. Majumdar, T. Sarmiento, K. Fischer, K. G. Lagoudakis, S. Buckley, A. Y. Piggott, and J. Vučković, “Nonclassical higher-order photon correlations with a quantum dot strongly coupled to a photonic-crystal nanocavity,” *Phys. Rev. A* **90**(2), 023846 (2014).

⁵⁵A. Faraon, E. Waks, D. Englund, I. Fushman, and J. Vučković, “Efficient photonic crystal cavity-waveguide couplers,” *Appl. Phys. Lett.* **90**(7), 073102 (2007).

⁵⁶F. Martini, A. Gaggero, F. Mattioli, and R. Leoni, "Single photon detection with superconducting nanowires on crystalline silicon carbide," *Opt. Express* **27**(21), 29669–29675 (2019).

⁵⁷F. Martini, A. Gaggero, F. Mattioli, and R. Leoni, "Electro-optical characterization of superconducting nanowire single-photon detectors fabricated on 3C silicon carbide," *J. Low Temp. Phys.* **199**(1), 563–568 (2020).

⁵⁸A. E. Lita, A. J. Miller, and S. W. Nam, "Counting near-infrared single-photons with 95% efficiency," *Opt. Express* **16**(5), 3032–3040 (2008).

⁵⁹F. Marsili, V. B. Verma, J. A. Stern, S. Harrington, A. E. Lita, T. Gerrits, I. Vayshenker, B. Baek, M. D. Shaw, R. P. Mirin *et al.*, "Detecting single infrared photons with 93% system efficiency," *Nat. Photonics* **7**(3), 210–214 (2013).

⁶⁰P. Rath, O. Kahl, S. Ferrari, F. Sproll, G. Lewes-Malandakis, D. Brink, K. Ilin, M. Siegel, C. Nebel, and W. Pernice, "Superconducting single-photon detectors integrated with diamond nanophotonic circuits," *Light Sci. Appl.* **4**(10), e338 (2015).

⁶¹G. Wolfowicz, F. J. Heremans, C. P. Anderson, S. Kanai, H. Seo, A. Gali, G. Galli, and D. D. Awschalom, "Quantum guidelines for solid-state spin defects," *Nat. Rev. Mater.* **6**, 906–925 (2021).

⁶²W. Dong, F. A. Calderon-Vargas, and S. E. Economou, "Precise high-fidelity electron-nuclear spin entangling gates in NV centers via hybrid dynamical decoupling sequences," *New J. Phys.* **22**(7), 073059 (2020).

⁶³D. P. DiVincenzo, "The physical implementation of quantum computation," *Fortschritte Phys.* **48**(9–11), 771–783 (2000).

⁶⁴P. C. Maurer, G. Kucsko, C. Latta, L. Jiang, N. Y. Yao, S. D. Bennett, F. Pastawski, D. Hunger, N. Chisholm, M. Markham *et al.*, "Room-temperature quantum bit memory exceeding one second," *Science* **336**(6086), 1283–1286 (2012).

⁶⁵A. Bourassa, C. P. Anderson, K. C. Miao, M. Onizhuk, H. Ma, A. L. Crook, H. Abe, J. Ul-Hassan, T. Ohshima, N. T. Son *et al.*, "Entanglement and control of single nuclear spins in isotopically engineered silicon carbide," *Nat. Mater.* **19**(12), 1319–1325 (2020).

⁶⁶C. Babin, R. Stöhr, N. Morioka, T. Linkewitz, T. Steidl, R. Wörnle, D. Liu, E. Hesselmeier, V. Vorobyov, A. Denisenko *et al.*, "Fabrication and nanophotonic waveguide integration of silicon carbide colour centres with preserved spin-optical coherence," *Nat. Mater.* **21**(1), 67–73 (2022).

⁶⁷L. Jiang, J. M. Taylor, K. Nemoto, W. J. Munro, R. Van Meter, and M. D. Lukin, "Quantum repeater with encoding," *Phys. Rev. A* **79**(3), 032325 (2009).

⁶⁸P. Neumann, N. Mizuuchi, F. Rempp, P. Hemmer, H. Watanabe, S. Yamasaki, V. Jacques, T. Gaebel, F. Jelezko, and J. Wrachtrup, "Multipartite entanglement among single spins in diamond," *Science* **320**(5881), 1326–1329 (2008).

⁶⁹A. Faraon, P. E. Barclay, C. Santori, K.-M. C. Fu, and R. G. Beausoleil, "Resonant enhancement of the zero-phonon emission from a colour centre in a diamond cavity," *Nat. Photonics* **5**(5), 301–305 (2011).

⁷⁰D. Riedel, I. Söllner, B. J. Shields, S. Starosielec, P. Appel, E. Neu, P. Maletinsky, and R. J. Warburton, "Deterministic enhancement of coherent photon generation from a nitrogen-vacancy center in ultrapure diamond," *Phys. Rev. X* **7**(3), 031040 (2017).

⁷¹M. W. Doherty, N. B. Manson, P. Delaney, F. Jelezko, J. Wrachtrup, and L. C. L. Hollenberg, "The nitrogen-vacancy colour centre in diamond," *Phys. Rep.* **528**(1), 1–45 (2013).

⁷²M. Ruf, M. I. Jspeert, S. Van Dam, N. De Jong, H. Van Den Berg, G. Evers, and R. Hanson, "Optically coherent nitrogen-vacancy centers in micrometer-thin etched diamond membranes," *Nano Lett.* **19**(6), 3987–3992 (2019).

⁷³A. Tchekbotareva, S. L. N. Hermans, P. C. Humphreys, D. Voigt, P. J. Harmsma, L. K. Cheng, A. L. Verlaan, N. Dijkhuizen, W. De Jong, A. Dréau *et al.*, "Entanglement between a diamond spin qubit and a photonic time-bin qubit at telecom wavelength," *Phys. Rev. Lett.* **123**(6), 063601 (2019).

⁷⁴D. D. Sukachev, A. Sipahigil, C. T. Nguyen, M. K. Bhaskar, R. E. Evans, F. Jelezko, and M. D. Lukin, "Silicon-vacancy spin qubit in diamond: A quantum memory exceeding 10 ms with single-shot state readout," *Phys. Rev. Lett.* **119**(22), 223602 (2017).

⁷⁵B. Pingault, D.-D. Jarausch, C. Hepp, L. Klinberg, J. N. Becker, M. Markham, C. Becher, and M. Atatüre, "Coherent control of the silicon-vacancy spin in diamond," *Nat. Commun.* **8**(1), 1–7 (2017).

⁷⁶P. Siyushev, M. H. Metsch, A. Ijaz, J. M. Binder, M. K. Bhaskar, D. D. Sukachev, A. Sipahigil, R. E. Evans, C. T. Nguyen, M. D. Lukin *et al.*, "Optical and microwave control of germanium-vacancy center spins in diamond," *Phys. Rev. B* **96**(8), 081201 (2017).

⁷⁷T. Iwasaki, Y. Miyamoto, T. Taniguchi, P. Siyushev, M. H. Metsch, F. Jelezko, and M. Hatano, "Tin-vacancy quantum emitters in diamond," *Phys. Rev. Lett.* **119**(25), 253601 (2017).

⁷⁸M. E. Trusheim, B. Pingault, N. H. Wan, M. Gündoğan, L. De Santis, R. Debroux, D. Gangloff, C. Purser, K. C. Chen, M. Walsh *et al.*, "Transform-limited photons from a coherent tin-vacancy spin in diamond," *Phys. Rev. Lett.* **124**(2), 023602 (2020).

⁷⁹M. E. Trusheim, N. H. Wan, K. C. Chen, C. J. Ciccarino, J. Flick, R. Sundararaman, G. Malladi, E. Bersin, M. Walsh, B. Lienhard *et al.*, "Lead-related quantum emitters in diamond," *Phys. Rev. B* **99**(7), 075430 (2019).

⁸⁰M. Atatüre, D. Englund, N. Vamivakas, S.-Y. Lee, and J. Wrachtrup, "Material platforms for spin-based photonic quantum technologies," *Nat. Rev. Mater.* **3**(5), 38–51 (2018).

⁸¹M. Widmann, S.-Y. Lee, T. Rendler, N. T. Son, H. Fedder, S. Paik, L.-P. Yang, N. Zhao, S. Yang, I. Booker *et al.*, "Coherent control of single spins in silicon carbide at room temperature," *Nat. Mater.* **14**(2), 164–168 (2015).

⁸²D. J. Christle, A. L. Falk, P. Andrich, P. V. Klimov, J. U-Hassan, N. T. Son, E. Janzén, T. Ohshima, and D. D. Awschalom, "Isolated electron spins in silicon carbide with millisecond coherence times," *Nat. Mater.* **14**(2), 160–163 (2015).

⁸³H. Seo, A. L. Falk, P. V. Klimov, K. C. Miao, G. Galli, and D. D. Awschalom, "Quantum decoherence dynamics of divacancy spins in silicon carbide," *Nat. Commun.* **7**(1), 1–9 (2016).

⁸⁴S. Castelletto, B. C. Johnson, V. Ivády, N. Stavrias, T. Umeda, A. Gali, and T. Ohshima, "A silicon carbide room-temperature single-photon source," *Nat. Mater.* **13**(2), 151–156 (2014).

⁸⁵A. L. Falk, P. V. Klimov, V. Ivády, K. Szász, D. J. Christle, W. F. Koehl, Á. Gali, and D. D. Awschalom, "Optical polarization of nuclear spins in silicon carbide," *Phys. Rev. Lett.* **114**(24), 247603 (2015).

⁸⁶P. V. Klimov, A. L. Falk, D. J. Christle, V. V. Dobrovitski, and D. D. Awschalom, "Quantum entanglement at ambient conditions in a macroscopic solid-state spin ensemble," *Sci. Adv.* **1**(10), e1501015 (2015).

⁸⁷L.-P. Yang, C. Burk, M. Widmann, S.-Y. Lee, J. Wrachtrup, and N. Zhao, "Electron spin decoherence in silicon carbide nuclear spin bath," *Phys. Rev. B* **90**(24), 241203 (2014).

⁸⁸S. Yang, Y. Wang, D. D. Bhaktavatsala Rao, T. H. Tran, A. S. Momenzadeh, M. Markham, D. J. Twitchen, P. Wang, W. Yang, R. Stöhr *et al.*, "High-fidelity transfer and storage of photon states in a single nuclear spin," *Nat. Photonics* **10**(8), 507–511 (2016).

⁸⁹D. Simin, V. A. Soltamov, A. V. Poshakinskiy, A. N. Anisimov, R. A. Babunts, D. O. Tolmachev, E. N. Mokhov, M. Trupke, S. A. Tarasenko, A. Sperlich *et al.*, "All-optical dc nanotesla magnetometry using silicon vacancy fine structure in isotopically purified silicon carbide," *Phys. Rev. X* **6**(3), 031014 (2016).

⁹⁰F. Sardi, T. Kornher, M. Widmann, R. Kolesov, F. Schiller, T. Reindl, M. Hagel, and J. Wrachtrup, "Scalable production of solid-immersion lenses for quantum emitters in silicon carbide," *Appl. Phys. Lett.* **117**(2), 022105 (2020).

⁹¹M. Radulaski, M. Widmann, M. Niethammer, J. Linda Zhang, S.-Y. Lee, T. Rendler, K. G. Lagoudakis, N. T. Son, E. Janzen, T. Ohshima *et al.*, "Scalable quantum photonics with single color centers in silicon carbide," *Nano Lett.* **17**(3), 1782–1786 (2017).

⁹²D. M. Lukin, C. Dory, M. A. Guidry, K. Y. Yang, S. D. Mishra, R. Trivedi, M. Radulaski, S. Sun, D. Vercruyse, G. H. Ahn *et al.*, "4H-silicon-carbide-on-insulator for integrated quantum and nonlinear photonics," *Nat. Photonics* **14**(5), 330–334 (2020).

⁹³C. Dory, D. Vercruyse, K. Youl Yang, N. V. Sapra, A. E. Rugar, S. Sun, D. M. Lukin, A. Y. Piggott, J. L. Zhang, M. Radulaski *et al.*, "Inverse-designed diamond photonics," *Nat. Commun.* **10**(1), 1–7 (2019).

⁹⁴M. J. Burek, C. Meuwly, R. E. Evans, M. K. Bhaskar, A. Sipahigil, S. Meesala, B. Machielse, D. D. Sukachev, C. T. Nguyen, J. L. Pacheco *et al.*, "Fiber-coupled

diamond quantum nanophotonic interface," *Phys. Rev. Appl.* **8**(2), 024026 (2017).

⁹⁵D. O. Bracher, X. Zhang, and E. L. Hu, "Selective purcell enhancement of two closely linked zero-phonon transitions of a silicon carbide color center," *Proc. Natl. Acad. Sci. U.S.A.* **114**(16), 4060–4065 (2017).

⁹⁶B.-S. Song, S. Yamada, T. Asano, and S. Noda, "Demonstration of two-dimensional photonic crystals based on silicon carbide," *Opt. Express* **19**(12), 11084–11089 (2011).

⁹⁷M. Radulaski, T. M. Babinec, S. Buckley, A. Rundquist, J. Provine, K. Alasaad, G. Ferro, and J. Vučković, "Photonic crystal cavities in cubic (3C) polytype silicon carbide films," *Opt. Express* **21**(26), 32623–32629 (2013).

⁹⁸B.-S. Song, T. Asano, S. Jeon, H. Kim, C. Chen, D. D. Kang, and S. Noda, "Ultrahigh-Q photonic crystal nanocavities based on 4H silicon carbide," *Optica* **6**(8), 991–995 (2019).

⁹⁹X. Lu, J. Y. Lee, P. X.-L. Feng, and Q. Lin, "Silicon carbide microdisk resonator," *Opt. Lett.* **38**(8), 1304–1306 (2013).

¹⁰⁰A. P. Magyar, D. Bracher, J. C. Lee, I. Aharonovich, and E. L. Hu, "High-quality SiC microdisk resonators fabricated from monolithic epilayer wafers," *Appl. Phys. Lett.* **104**(5), 051109 (2014).

¹⁰¹B.-S. Song, S. Jeon, H. Kim, D. Daniel Kang, T. Asano, and S. Noda, "High-Q-factor nanobeam photonic crystal cavities in bulk silicon carbide," *Appl. Phys. Lett.* **113**(23), 231106 (2018).

¹⁰²G. Calusine, A. Politi, and D. D. Awschalom, "Silicon carbide photonic crystal cavities with integrated color centers," *Appl. Phys. Lett.* **105**(1), 011123 (2014).

¹⁰³G. Calusine, A. Politi, and D. D. Awschalom, "Cavity-enhanced measurements of defect spins in silicon carbide," *Phys. Rev. Appl.* **6**(1), 014019 (2016).

¹⁰⁴E. Janitz, M. K. Bhaskar, and L. Childress, "Cavity quantum electrodynamics with color centers in diamond," *Optica* **7**(10), 1232–1252 (2020).

¹⁰⁵J. Borregaard, A. S. Sørensen, and P. Lodahl, "Quantum networks with deterministic spin–photon interfaces," *Adv. Quant. Technol.* **2**(5–6), 1800091 (2019).

¹⁰⁶A. Reiserer and G. Rempe, "Cavity-based quantum networks with single atoms and optical photons," *Rev. Mod. Phys.* **87**(4), 1379 (2015).

¹⁰⁷I. Diniz, S. Portolan, R. Ferreira, J. M. Gérard, P. Bertet, and A. Auffeves, "Strongly coupling a cavity to inhomogeneous ensembles of emitters: Potential for long-lived solid-state quantum memories," *Phys. Rev. A* **84**(6), 063810 (2011).

¹⁰⁸G. Balasubramanian, P. Neumann, D. Twitchen, M. Markham, R. Kolesov, N. Mizuochi, J. Isoya, J. Achard, J. Beck, J. Tissler *et al.*, "Ultralong spin coherence time in isotopically engineered diamond," *Nat. Mater.* **8**(5), 383–387 (2009).

¹⁰⁹L. Jiang and R. Cheung, "Impact of Ar addition to inductively coupled plasma etching of SiC in SF₆/O₂," *Microelectron. Eng.* **73**, 306–311 (2004).

¹¹⁰J. H. Choi, L. Latu-Romain, E. Bano, F. Dhalluin, T. Chevolleau, and T. Baron, "Fabrication of SiC nanopillars by inductively coupled SF₆/O₂ plasma etching," *J. Phys. D: Appl. Phys.* **45**(23), 235204 (2012).

¹¹¹K. M. Dowling, E. H. Ransom, and D. G. Senesky, "Profile evolution of high aspect ratio silicon carbide trenches by inductive coupled plasma etching," *J. Microelectromech. Syst.* **26**(1), 135–142 (2016).

¹¹²M. J. Polking, A. M. Dibos, N. P. de Leon, and H. Park, "Improving defect-based quantum emitters in silicon carbide via inorganic passivation," *Adv. Mater.* **30**(4), 1704543 (2018).

¹¹³J. Cardenas, M. Zhang, C. T. Phare, S. Y. Shah, C. B. Poitras, B. Guha, and M. Lipson, "High Q SiC microresonators," *Opt. Express* **21**(14), 16882–16887 (2013).

¹¹⁴X. Lu, J. Y. Lee, P. X.-L. Feng, and Q. Lin, "High Q silicon carbide microdisk resonator," *Appl. Phys. Lett.* **104**(18), 181103 (2014).

¹¹⁵L. D. Cioccio, F. Letertre, Y. L. Tiec, A. M. Papon, C. Jaussaud, and M. Bruel, "Silicon carbide on insulator formation by the smart-cut® process," *Mater. Sci. Eng. B* **46**(1–3), 349–356 (1997).

¹¹⁶D. O. Bracher and E. L. Hu, "Fabrication of high-Q nanobeam photonic crystals in epitaxially grown 4H-SiC," *Nano Lett.* **15**(9), 6202–6207 (2015).

¹¹⁷M. J. Burek, N. P. De Leon, B. J. Shields, B. J. M. Hausmann, Y. Chu, Q. Quan, A. S. Zibrov, H. Park, M. D. Lukin, and M. Lončar, "Free-standing mechanical and photonic nanostructures in single-crystal diamond," *Nano Lett.* **12**(12), 6084–6089 (2012).

¹¹⁸H. A. Atikian, P. Latawiec, M. J. Burek, Y.-I. Sohn, S. Meesala, N. Gravel, A. B. Kouki, and M. Lončar, "Freestanding nanostructures via reactive ion beam angled etching," *APL Photonics* **2**(5), 051301 (2017).

¹¹⁹S. Mosor, J. Hendrickson, B. C. Richards, J. Sweet, G. Khitrova, H. M. Gibbs, T. Yoshiie, A. Scherer, O. B. Shchekin, and D. G. Deppe, "Scanning a photonic crystal slab nanocavity by condensation of xenon," *Appl. Phys. Lett.* **87**(14), 141105 (2005).

¹²⁰J. L. Zhang, S. Sun, M. J. Burek, C. Dory, Y.-K. Tzeng, K. A. Fischer, Y. Kelaita, K. G. Lagoudakis, M. Radulaski, Z.-X. Shen *et al.*, "Strongly cavity-enhanced spontaneous emission from silicon-vacancy centers in diamond," *Nano Lett.* **18**(2), 1360–1365 (2018).

¹²¹C. P. Anderson, A. Bourassa, K. C. Miao, G. Wolfowicz, P. J. Mintun, A. L. Crook, H. Abe, J. Ul-Hassan, N. T. Son, T. Ohshima *et al.*, "Electrical and optical control of single spins integrated in scalable semiconductor devices," *Science* **366**(6470), 1225–1230 (2019).

¹²²M. Rühl, L. Bergmann, M. Krieger, and H. B. Weber, "Stark tuning of the silicon vacancy in silicon carbide," *Nano Lett.* **20**(1), 658–663 (2019).

¹²³C. F. de las Casas, D. J. Christle, J. Ul-Hassan, T. Ohshima, N. T. Son, and D. D. Awschalom, "Stark tuning and electrical charge state control of single divacancies in silicon carbide," *Appl. Phys. Lett.* **111**(26), 262403 (2017).

¹²⁴M. E. Bathen, A. Galeckas, J. Müting, H. M. Ayedh, U. Grossner, J. Coutinho, Y. K. Frodason, and L. Vines, "Electrical charge state identification and control for the silicon vacancy in 4H-SiC," *npj Quant. Information* **5**(1), 1–9 (2019).

¹²⁵S. Meesala, Y.-I. Sohn, B. Pingault, L. Shao, H. A. Atikian, J. Holzgrafe, M. Gündoğan, C. Stavrakas, A. Sipahigil, C. Chia *et al.*, "Strain engineering of the silicon-vacancy center in diamond," *Phys. Rev. B* **97**(20), 205444 (2018).

¹²⁶B. Machielse, S. Bogdanovic, S. Meesala, S. Gauthier, M. J. Burek, G. Joe, M. Chalupnik, Y.-I. Sohn, J. Holzgrafe, R. E. Evans *et al.*, "Quantum interference of electromechanically stabilized emitters in nanophotonic devices," *Phys. Rev. X* **9**(3), 031022 (2019).

¹²⁷G. Wolfowicz, C. P. Anderson, A. L. Yeats, S. J. Whiteley, J. Niklas, O. G. Poluektov, F. J. Heremans, and D. D. Awschalom, "Optical charge state control of spin defects in 4H-SiC," *Nat. Commun.* **8**(1), 1–9 (2017).

¹²⁸M. Widmann, M. Niethammer, D. Y. Fedyanin, I. A. Khramtsov, T. Rendler, I. D. Booker, J. Ul-Hassan, N. Morioka, Y.-C. Chen, I. G. Ivanov *et al.*, "Electrical charge state manipulation of single silicon vacancies in a silicon carbide quantum optoelectronic device," *Nano Lett.* **19**(10), 7173–7180 (2019).

¹²⁹M. Niethammer, M. Widmann, T. Rendler, N. Morioka, Y.-C. Chen, R. Stöhr, J. Ul-Hassan, S. Onoda, T. Ohshima, S.-Y. Lee *et al.*, "Coherent electrical readout of defect spins in silicon carbide by photo-ionization at ambient conditions," *Nat. Commun.* **10**(1), 1–8 (2019).

¹³⁰J. Wang, X. Zhang, Y. Zhou, K. Li, Z. Wang, P. Peddibhotla, F. Liu, S. Bauerdick, A. Rudzinski, Z. Liu *et al.*, "Scalable fabrication of single silicon vacancy defect arrays in silicon carbide using focused ion beam," *ACS Photonics* **4**(5), 1054–1059 (2017).

¹³¹Y.-C. Chen, P. S. Salter, M. Niethammer, M. Widmann, F. Kaiser, R. Nagy, N. Morioka, C. Babin, J. Erlekampf, P. Berwian *et al.*, "Laser writing of scalable single color centers in silicon carbide," *Nano Lett.* **19**(4), 2377–2383 (2019).

¹³²A. F. M. Almutairi, J. G. Partridge, C. Xu, I. S. Cole, and A. S. Holland, "Direct writing of divacancy centers in silicon carbide by femtosecond laser irradiation and subsequent thermal annealing," *Appl. Phys. Lett.* **120**(1), 014003 (2022).

¹³³H. Kraus, D. Simin, C. Kasper, Y. Suda, S. Kawabata, W. Kada, T. Honda, Y. Hijikata, T. Ohshima, V. Dyakonov *et al.*, "Three-dimensional proton beam writing of optically active coherent vacancy spins in silicon carbide," *Nano Lett.* **17**(5), 2865–2870 (2017).

¹³⁴J. Wang, Y. Zhou, X. Zhang, F. Liu, Y. Li, K. Li, Z. Liu, G. Wang, and W. Gao, "Efficient generation of an array of single silicon-vacancy defects in silicon carbide," *Phys. Rev. Appl.* **7**(6), 064021 (2017).

¹³⁵A. L. Falk, P. V. Klimov, B. B. Buckley, V. Ivády, I. A. Abrikosov, G. Calusine, W. F. Koehl, Á. Gali, and D. D. Awschalom, "Electrically and mechanically tunable electron spins in silicon carbide color centers," *Phys. Rev. Lett.* **112**(18), 187601 (2014).

¹³⁶P. Udvarhelyi and A. Gali, "Ab initio spin-strain coupling parameters of divacancy qubits in silicon carbide," *Phys. Rev. Appl.* **10**(5), 054010 (2018).

¹³⁷G. C. Vasquez, M. E. Batten, A. Galeckas, C. Bazioti, K. M. Johansen, D. Maestre, A. Cremades, Ø. Prytz, A. M. Moe, A. Y. Kuznetsov *et al.*, "Strain modulation of Si vacancy emission from SiC micro-and nanoparticles," *Nano Lett.* **20**(12), 8689–8695 (2020).

¹³⁸I. D. Breev, A. V. Poshakinskiy, V. V. Yakovleva, S. S. Nagalyuk, E. N. Mokhov, R. Hübner, G. V. Astakhov, P. G. Baranov, and A. N. Anisimov, "Stress-controlled zero-field spin splitting in silicon carbide," *Appl. Phys. Lett.* **118**(8), 084003 (2021).

¹³⁹S. J. Whiteley, G. Wolfowicz, C. P. Anderson, A. Bourassa, H. Ma, M. Ye, G. Koolstra, K. J. Satzinger, M. V. Holt, F. J. Heremans *et al.*, "Spin-phonon interactions in silicon carbide addressed by gaussian acoustics," *Nat. Phys.* **15**(5), 490–495 (2019).

¹⁴⁰C. T. Nguyen, D. D. Sukachev, M. K. Bhaskar, B. Machielse, D. S. Levonian, E. N. Knall, P. Stroganov, C. Chia, M. J. Burek, R. Riedinger *et al.*, "An integrated nanophotonic quantum register based on silicon-vacancy spins in diamond," *Phys. Rev. B* **100**(16), 165428 (2019).

¹⁴¹N. Kalb, A. A. Reiserer, P. C. Humphreys, J. J. W. Bakermans, S. J. Kamerling, N. H. Nickerson, S. C. Benjamin, D. J. Twitchen, M. Markham, and R. Hanson, "Entanglement distillation between solid-state quantum network nodes," *Science* **356**(6341), 928–932 (2017).

¹⁴²L.-C. Lu, G.-Y. Wang, B.-C. Ren, M. Zhang, and F.-G. Deng, "Heralded entanglement purification protocol using high-fidelity parity-check gate based on nitrogen-vacancy center in optical cavity," *Chin. Phys. B* **29**(1), 010305 (2020).

¹⁴³W. J. Munro, K. Azuma, K. Tamaki, and K. Nemoto, "Inside quantum repeaters," *IEEE J. Sel. Top. Quantum Electron.* **21**(3), 78–90 (2015).

¹⁴⁴L. Jiang, J. M. Taylor, N. Khaneja, and M. D. Lukin, "Optimal approach to quantum communication using dynamic programming," *Proc. Natl. Acad. Sci. U.S.A.* **104**(44), 17291–17296 (2007).

¹⁴⁵W. J. Munro, K. A. Harrison, A. M. Stephens, S. J. Devitt, and K. Nemoto, "From quantum multiplexing to high-performance quantum networking," *Nat. Photonics* **4**(11), 792–796 (2010).

¹⁴⁶A. G. Fowler, D. S. Wang, C. D. Hill, T. D. Ladd, R. Van Meter, and L. C. L. Hollenberg, "Surface code quantum communication," *Phys. Rev. Lett.* **104**(18), 180503 (2010).

¹⁴⁷W. J. Munro, A. M. Stephens, S. J. Devitt, K. A. Harrison, and K. Nemoto, "Quantum communication without the necessity of quantum memories," *Nat. Photonics* **6**(11), 777–781 (2012).

¹⁴⁸S. Muralidharan, J. Kim, N. Lütkenhaus, M. D. Lukin, and L. Jiang, "Ultrafast and fault-tolerant quantum communication across long distances," *Phys. Rev. Lett.* **112**(25), 250501 (2014).

¹⁴⁹S. Muralidharan, L. Li, J. Kim, N. Lütkenhaus, M. D. Lukin, and L. Jiang, "Optimal architectures for long distance quantum communication," *Sci. Rep.* **6**(1), 1–10 (2016).

¹⁵⁰V. Ivády, P. V. Klimov, K. C. Miao, A. L. Falk, D. J. Christle, K. Szász, I. A. Abrikosov, D. D. Awschalom, and A. Gali, "High-fidelity bidirectional nuclear qubit initialization in SiC," *Phys. Rev. Lett.* **117**(22), 220503 (2016).

¹⁵¹H. B. Banks, Ö. O. Soykal, R. L. Myers-Ward, D. K. Gaskill, T. L. Reinecke, and S. G. Carter, "Resonant optical spin initialization and readout of single silicon vacancies in 4H-SiC," *Phys. Rev. Appl.* **11**(2), 024013 (2019).

¹⁵²K. Azuma, K. Tamaki, and H.-K. Lo, "All-photonic quantum repeaters," *Nat. Commun.* **6**(1), 1–7 (2015).

¹⁵³M. Zwerger, W. Dür, and H. J. Briegel, "Measurement-based quantum repeaters," *Phys. Rev. A* **85**(6), 062326 (2012).

¹⁵⁴M. Zwerger, H. J. Briegel, and W. Dür, "Universal and optimal error thresholds for measurement-based entanglement purification," *Phys. Rev. Lett.* **110**(26), 260503 (2013).

¹⁵⁵D. Buterakos, E. Barnes, and S. E. Economou, "Deterministic generation of all-photonic quantum repeaters from solid-state emitters," *Phys. Rev. X* **7**(4), 041023 (2017).

¹⁵⁶S. E. Economou and P. Dev, "Spin-photon entanglement interfaces in silicon carbide defect centers," *Nanotechnology* **27**(50), 504001 (2016).

¹⁵⁷P. Hilaire, E. Barnes, and S. E. Economou, "Resource requirements for efficient quantum communication using all-photonic graph states generated from a few matter qubits," *Quantum* **5**, 397 (2021).

¹⁵⁸M. J. Hartmann, F. G. S. L. Brandao, and M. B. Plenio, "Quantum many-body phenomena in coupled cavity arrays," *Laser Photonics Rev.* **2**(6), 527–556 (2008).

¹⁵⁹B. Bujnowski, J. K. Corso, A. L. C. Hayward, J. H. Cole, and A. M. Martin, "Supersolid phases of light in extended Jaynes-Cummings-Hubbard systems," *Phys. Rev. A* **90**(4), 043801 (2014).

¹⁶⁰J. M. Raimond, M. Brune, and S. Haroche, "Manipulating quantum entanglement with atoms and photons in a cavity," *Rev. Mod. Phys.* **73**, 565–582 (2001).

¹⁶¹H. J. Kimble, "Strong interactions of single atoms and photons in cavity QED," *Phys. Scr.* **1998**(T76), 127 (1998).

¹⁶²E. Peter, P. Senellart, D. Martrou, A. Lemaître, J. Hours, J. M. Gérard, and J. Bloch, "Exciton-photon strong-coupling regime for a single quantum dot embedded in a microcavity," *Phys. Rev. Lett.* **95**(6), 067401 (2005).

¹⁶³J. McKeever, A. Boca, A. D. Boozer, J. R. Buck, and H. J. Kimble, "Experimental realization of a one-atom laser in the regime of strong coupling," *Nature* **425**(6955), 268–271 (2003).

¹⁶⁴A. Wallraff, D. I. Schuster, A. Blais, L. Frunzio, R.-S. Huang, J. Majer, S. Kumar, S. M. Girvin, and R. J. Schoelkopf, "Strong coupling of a single photon to a superconducting qubit using circuit quantum electrodynamics," *Nature* **431**(7005), 162–167 (2004).

¹⁶⁵S. Majety, V. A. Norman, L. Li, M. Bell, P. Saha, and M. Radulaski, "Quantum photonics in triangular-cross-section nanodevices in silicon carbide," *J. Phys. B* **3**(3), 034008 (2021).

¹⁶⁶J. Patton, V. A. Norman, R. T. Scalettar, and M. Radulaski, "All-photonic quantum simulators with spectrally disordered emitters," *arXiv:2112.15469* (2021).

¹⁶⁷M. Radulaski, K. A. Fischer, and J. Vučković, "Nonclassical light generation from iii–v and group-iv solid-state cavity quantum systems," *Adv. At. Mol. Opt. Phys.* **66**, 111–179 (2017).

¹⁶⁸R. Trivedi, M. Radulaski, K. A. Fischer, S. Fan, and J. Vučković, "Photon blockade in weakly-driven cavity QED systems with many emitters," *arXiv:1901.03942* (2019).

¹⁶⁹R. Raussendorf and H. J. Briegel, "A one-way quantum computer," *Phys. Rev. Lett.* **86**(22), 5188 (2001).

¹⁷⁰R. Raussendorf, D. E. Browne, and H. J. Briegel, "Measurement-based quantum computation on cluster states," *Phys. Rev. A* **68**(2), 022312 (2003).

¹⁷¹Y. L. Lim, S. D. Barrett, A. Beige, P. Kok, and L. C. Kwek, "Repeat-until-success quantum computing using stationary and flying qubits," *Phys. Rev. A* **73**(1), 012304 (2006).

¹⁷²R. Beals, S. Brierley, O. Gray, A. W. Harrow, S. Kutin, N. Linden, D. Shepherd, and M. Stather, "Efficient distributed quantum computing," *Proc. R. Soc. A* **469**(2153), 20120686 (2013).

¹⁷³R. Van Meter and S. J. Devitt, "The path to scalable distributed quantum computing," *Computer* **49**(9), 31–42 (2016).

¹⁷⁴M. Varnava, D. E. Browne, and T. Rudolph, "Loss tolerance in one-way quantum computation via counterfactual error correction," *Phys. Rev. Lett.* **97**(12), 120501 (2006).

¹⁷⁵Y. Zhan and S. Sun, "Deterministic generation of loss-tolerant photonic cluster states with a single quantum emitter," *Phys. Rev. Lett.* **125**(22), 223601 (2020).

¹⁷⁶M. A. Nielsen and C. M. Dawson, "Fault-tolerant quantum computation with cluster states," *Phys. Rev. A* **71**(4), 042323 (2005).

¹⁷⁷R. Raussendorf, J. Harrington, and K. Goyal, "Topological fault-tolerance in cluster state quantum computation," *New J. Phys.* **9**(6), 199 (2007).

¹⁷⁸M. A. Nielsen, "Optical quantum computation using cluster states," *Phys. Rev. Lett.* **93**(4), 040503 (2004).

¹⁷⁹E. Knill, R. Laflamme, and G. J. Milburn, "A scheme for efficient quantum computation with linear optics," *Nature* **409**(6816), 46–52 (2001).

¹⁸⁰S. Bose, P. L. Knight, M. B. Plenio, and V. Vedral, "Proposal for teleportation of an atomic state via cavity decay," *Phys. Rev. Lett.* **83**(24), 5158 (1999).

¹⁸¹S. C. Benjamin, B. W. Lovett, and J. M. Smith, "Prospects for measurement-based quantum computing with solid state spins," *Laser Photonics Rev.* **3**(6), 556–574 (2009).

¹⁸²D. E. Browne and T. Rudolph, "Resource-efficient linear optical quantum computation," *Phys. Rev. Lett.* **95**(1), 010501 (2005).

¹⁸³X.-L. Wang, L.-K. Chen, W. Li, H.-L. Huang, C. Liu, C. Chen, Y.-H. Luo, Z.-E. Su, D. Wu, Z.-D. Li *et al.*, "Experimental ten-photon entanglement," *Phys. Rev. Lett.* **117**(21), 210502 (2016).

¹⁸⁴N. H. Lindner and T. Rudolph, "Proposal for pulsed on-demand sources of photonic cluster state strings," *Phys. Rev. Lett.* **103**(11), 113602 (2009).

¹⁸⁵S. E. Economou, N. Lindner, and T. Rudolph, "Optically generated 2-dimensional photonic cluster state from coupled quantum dots," *Phys. Rev. Lett.* **105**(9), 093601 (2010).

¹⁸⁶A. Russo, E. Barnes, and S. E. Economou, "Photonic graph state generation from quantum dots and color centers for quantum communications," *Phys. Rev. B* **98**(8), 085303 (2018).

¹⁸⁷M. Gimeno-Segovia, T. Rudolph, and S. E. Economou, "Deterministic generation of large-scale entangled photonic cluster state from interacting solid state emitters," *Phys. Rev. Lett.* **123**(7), 070501 (2019).

¹⁸⁸A. Russo, E. Barnes, and S. E. Economou, "Generation of arbitrary all-photonic graph states from quantum emitters," *New J. Phys.* **21**(5), 055002 (2019).

¹⁸⁹M. A. Guidry, K. Y. Yang, D. M. Lukin, A. Markosyan, J. Yang, M. M. Fejer, J. Vučković, *Optica* **7**, 1139–1142 (2020).